

Nanoribbons: From fundamentals to state-of-the-art applications

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Atomically thin nanoribbons (NRs) have been at the forefront of materials science and nanoelectronics in recent years. State-of-the-art research on nanoscale materials has revealed that electronic, magnetic, phononic, and optical properties may differ dramatically when their one-dimensional forms are synthesized. The present article aims to review the recent advances in synthesis techniques and theoretical studies on NRs. The structure of the review is organized as follows: After a brief introduction to low dimensional materials, we review different experimental techniques for the synthesis of graphene nanoribbons (GNRs) with their advantages and disadvantages. In addition, theoretical investigations on width and edge-shape-dependent electronic and magnetic properties, functionalization effects, and quantum transport properties of GNRs are reviewed. We then devote time to the NRs of the transition metal dichalcogenides (TMDs) family. First, various synthesis techniques, E-field-tunable electronic and magnetic properties, and edge-dependent thermoelectric performance of NRs of MoS₂ and WS₂ are discussed. Then, strongly anisotropic properties, growth-dependent morphology, and the weakly width-dependent bandgap of ReS₂ NRs are summarized. Next we discuss TMDs having a T-phase morphology such as TiSe₂ and stable single layer NRs of mono-chalcogenides. Strong edge-type dependence on characteristics of GaS NRs, width-dependent Seebeck coefficient of SnSe NRs, and experimental analysis on the stability of ZnSe NRs are reviewed. We then focus on the most recently emerging NRs belonging to the class of transition metal trichalcogenides which provide ultra-high electron mobility and highly anisotropic quasi-1D properties. In addition, width-, edge-shape-, and functionalization-dependent electronic and mechanical properties of blackphosphorus, a monoatomic anisotropic material, and studies on NRs of group IV elements (silicene, germanene, and stanene) are reviewed. Observation of substrate-independent quantum well states, edge and width dependent properties, the topological phase of silicene NRs are reviewed. In addition, H₂ concentration-dependent transport properties and anisotropic dielectric function of GeNRs and electric field and strain sensitive I–V characteristics of SnNRs are reviewed. We review both experimental and theoretical studies on the NRs of group III–V compounds. While defect and N-termination dependent conductance are highlighted for boron nitride NRs, aluminum nitride NRs are of importance due to their dangling bond, electric field, and strain dependent electronic and magnetic properties. Finally, superlattice structure of NRs of GaN/AlN, Si/Ge, G/BN, and MoS₂/WS₂ is reviewed. *Published by AIP Publishing.*

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I. INTRODUCTION

Over the past thirty years, low-dimensional structures such as wells, wires, and dots have been the focus of interest in materials science. In this material class, confinement of electrons, holes, and excitations in certain directions leads to dramatic changes in electronic, vibrational, optical, thermal, and chemical properties. Unique properties of low-dimensional crystals stem from quantum effects that emerge when at least one of the three dimensions of the crystal is reduced to a sufficiently small size, generally in the range from 1 to 100 nm.

While two-dimensional (2D) thin crystals limit the physical phenomena into a plane, in a one-dimensional (1D) quantum structure (nanowires, nanotubes, and nanoribbons (NRs)), charge carriers and excitations have only one degree of freedom. These crystal structures have been the focus of interest due to their unique properties such as very high electronic density of states, enhanced exciton binding energy, diameter-dependent bandgap, increased surface scattering for electrons and phonons, and chirality-dependent electronic band structure.

Nanoribbons (NRs), made of single- or few-atom-thick lamellar crystals, are novel forms of 1D nanoscale materials and are ideal systems for investigation of the size and dimensionality dependence of the fundamental properties. After successful synthesis of many 2D monolayer materials, their 1D NR form came into prominence due to their necessity in nanoscale applications. In this context, here we present an extensive review on NRs of recent 2D materials such as graphene, transition metal dichalcogenides (TMDs) (MoS_2 , WS_2 , ReS_2 , and TiSe_2), mono-chalcogenides (GaS , GaSe , ZnSe , and SnSe), tri-chalcogenides (TiS_3 and ZrS_3), blackphosphorus, group-IV, III–V binary compounds, and superstructures.

II. THE RISE OF SINGLE LAYER NRs: GRAPHENE

The first breakthrough in 2D atomic-thick materials started following the successful isolation of graphene from its bulk counterpart, graphite, in 2004.¹ Graphene, which is simply an atomic-thin sheet of hexagonally arranged C atoms, has many unique physical properties such as being the thinnest but mechanically the strongest and stiffest material.² In addition, graphene is not only mechanically but also electronically a unique material. It has been demonstrated that linear crossing of valence and conduction band edges at the Fermi level provides a very high electron mobility of $15 \times 10^3 \text{ cm}^2/\text{Vs}$ and quite high thermal conductivity.^{3,4}

As a consequence of their hexagonal lattice symmetry, NRs of graphene can form zigzag and armchair shaped edges

which directly determine their magnetic and electronic properties. Theory predicted that depending on their edge shape and the width, graphene nanoribbons (GNRs) can possess magnetic metallic or nonmagnetic (NM) semiconducting ground states which was confirmed in a recent experiment. Recent experiments demonstrated that GNRs can be synthesized successfully with controllable structural and electronic properties.^{5,6} Since GNRs provide a rich playground, recent efforts have focused on the synthesis and deeper understanding of these materials.

A. Synthesis and fabrication techniques

Atomic structure and the resulting characteristic properties of GNRs strongly depend on how the GNR is synthesized. There are three main experimental methods available to fabricate GNRs: (i) cutting graphene along special directions by using lithography, (ii) bottom-up synthesis from precursor molecules, and (iii) unzipping of carbon nanotubes (CNTs).

The bottom-up fabrication technique allows one to synthesize very narrow ribbons with precise edge configurations. One of the first successful syntheses of narrow GNRs was reported by Li *et al.* They developed a chemical route to produce GNRs having widths below 10 nm and single NRs with varying widths.⁵ Instead of using lithography which is unable to produce smooth edges, they chemically exfoliated graphite in dichloroethane (DCE) solution of poly(m-phenylenevinylene-co-2,5-dioctoxy-p-phenylenevinylene) (PmPV) by sonication which resulted in GNRs with desired shape and dimensions. For measurement and characterization of GNRs, atomic force microscopy (AFM) was used and GNRs with various widths ranging from ~ 50 nm down to sub-10 nm were observed (see Fig. 1).

An alternative method of producing atomically precise NRs having different topologies and widths, by using surface-assisted coupling of molecular precursors (such as 6,11-dibromo-1,2,3,4-tetraphenyltriphenylene monomers), was reported by Cai *et al.*⁶ However, study of Vo *et al.* on narrow armchair GNRs (AGNRs) (~ 1 nm) synthesized by a novel bottom-up approach⁷ revealed that the ribbons have a large electronic bandgap of ~ 1.3 eV, a large aspect ratio, and a length of >100 nm. These large values of bandgap and ribbon length are quite promising for applications in high on-off ratios field-effect transistors and photovoltaic devices. Kimouche *et al.* studied the fabrication of GNRs with atomically well-defined armchair edges.⁸ They reported the synthesis of the narrowest possible GNR having a width of five carbon atoms by using a bottom-up approach technique (see Fig. 2). The evolution of the electronic bandgap as a function of GNRs length was investigated using low-temperature scanning tunneling microscopy. It was found that the synthesized ultra-narrow GNRs (five C-atom wide, $N = 5$) display nearly metallic behavior as predicted theoretically. The main point of their study is that the synthesized armchair GNRs can be used as molecular wires exhibiting metallic behavior at room temperature.

In another study, Bai *et al.* reported a rational approach for the fabrication of GNRs with sub-10 nm width by utilizing chemically synthesized nanowires as the physical protection

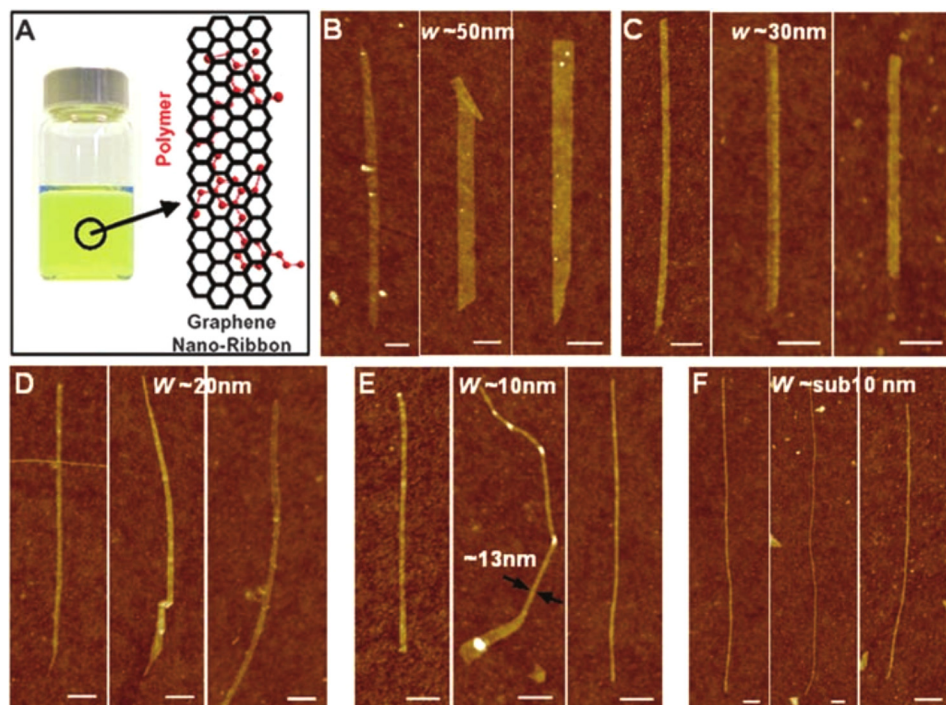


FIG. 1. (a) PmPV/DCE solution with GNRs on the left side and a simulation of GNR with PmPV polymer adsorbed on GNR. (b)–(f) AFM images of GNRs with widths ranging from 50 nm to sub-10 nm. All scale bars indicate 100 nm. Reprinted with permission from Li *et al.*, *Science* **319**, 1229 (2008). Copyright 2008 The American Association for the Advancement of Science.

mask in oxygen plasma etch. The important point of their study is to fabricate GNRs in a predictable and controllable manner.⁹ It was reported that the width of the fabricated GNRs scales well with the diameter of the nanowire and the etching time. Their fabricated GNRs have widths varying from 6 to

30 nm. One of the advantages of the technique used by Bai *et al.* is that they are able to control the width of the fabricated GNRs by the diameter of the used nanowire mask. Another advantage is the relatively smooth etching edge owing to the uniformity and smoothness of the mask nanowires. Very recently by a similar methodology, Ruffieux *et al.* reported the synthesis of GNRs with a zigzag edge topology.¹⁰ They demonstrated a bottom-up synthesis of zigzag graphene NRs (ZGNRs) through surface-assisted polymerization and cyclodehydrogenation of special precursor monomers. Although it was theoretically predicted, the observation of spin-polarized edge states in ZGNRs has not yet been achieved in the experiments. However, by using scanning tunneling spectroscopy (STS) they showed the existence of edge-localized states with large energy splittings in ZGNRs. As mentioned in their study, it is important to control the edge modification of ZGNRs by reducing the ZGNR substrate interaction. Campos *et al.* fabricated GNRs with sub-10 nm width using anisotropic etching of monolayer graphene by thermally activated nickel (Ni) nanoparticles.¹¹ A new catalytic channeling behavior was observed and etched cuts of graphene result in continuously connected geometries. Their Raman spectroscopy and electronic measurements indicate that the quality of graphene does not strongly depend on the etching conditions. Thus, the mentioned method may be a powerful tool to obtain GNRs with well-defined edges.

Atomic force microscopy (AFM) based local anodic oxidation (LAO) lithography has been used to fabricate micro- and nano-structures on different substrates. It is possible to include the ability to pattern surfaces with nanometer resolution by LAO lithography technique. Weng *et al.* demonstrated a fabrication method based on the local oxidation nanopatterning of graphene using AFM.¹² 25 nm-wide GNRs were fabricated by local anodic oxidation (LAO) lithography which has the advantage of monitoring the device parameters (such

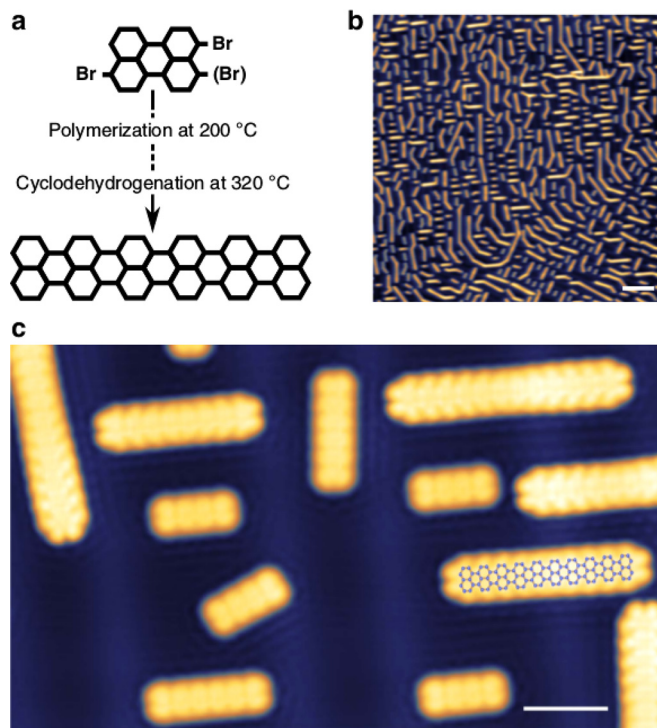


FIG. 2. Bottom-up synthesis of $N=5$ wide armchair GNRs. (a) Reaction scheme of the polymerization with dibromoperylene (DBP) molecular precursor to atomically well defined $N=5$ armchair GNRs, (b) STM image after cyclodehydrogenation process at 320 °C (scale bar, 10 nm), and (c) zoomed-in STM topography of different ribbon lengths (scale bar, 2 nm). Reprinted with permission from Kimouche *et al.*, *Nat. Commun.* **6**, 10177 (2015). Copyright 2015 Nature Publishing Group.

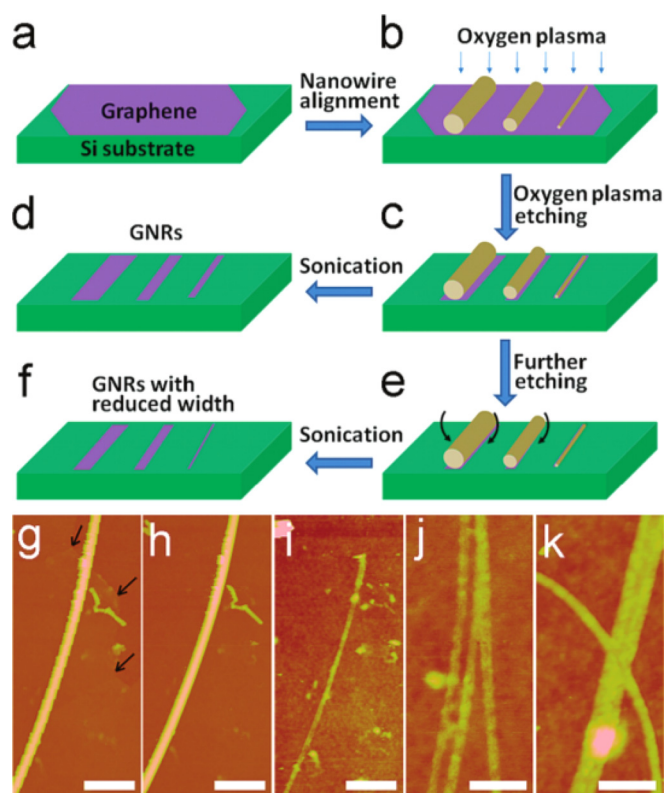


FIG. 3. (a)–(f) The schematic fabrication process of obtaining GNRs by oxygen plasma etch with a nanowire etch mask and (g) and (h) are AFM images of a nanowire etch mask lying on top of a graphene flake before (g) and after (h) the oxygen plasma etch. The scale bars are 300 nm and 100 nm in ((g)–(i)) and ((j) and (k)), respectively. Reprinted with permission from Bai *et al.*, *Nano Lett.* **9**, 2083 (2009). Copyright 2009 American Chemical Society.

as dimensions or electrical conduction) during the fabrication process. The same technique was also used by Masubuchi *et al.* in single-layer, bilayer, and multilayer graphenes, and 55 nm-wide GNRs were fabricated.¹³

Unzipping is a technique that cuts multiwalled carbon nanotube (MWCNT) crossway to form GNRs having width which depends on the diameter of the CNT. Kosynkin *et al.* fabricated GNRs by longitudinally unzipping MWCNT using

the oxidation technique.¹⁴ Such a lengthwise cutting was demonstrated for the first time. The same methodology was also used by Jiao *et al.* to produce smooth edge and narrow width GNRs.¹⁵ In their study, plasma etching of nanotubes in a polymer film was reported and GNRs were obtained by unzipping MWCNTs (see Fig. 3). The advantage of their approach is that GNRs can be realized with controlled widths and edge structures with high quality by controlling the placement and alignment of CNTs. It was also pointed out that the use of few-walled CNTs leads to the production of sub-10 nm GNRs with bandgaps which are sufficient for room-temperature transistor applications. Jiao *et al.* reported the synthesis of pristine few-layer NRs by unzipping gas-phase oxidized MWCNTs using mechanical sonication in an organic solvent.¹⁶ It was reported that the fabricated GNRs are of very high quality with very smooth edges. In addition, the produced GNRs have the highest electrical conductance and mobility ever reported to date (up to $5e^2/h$ and $1.500 \text{ cm}^2/\text{V s}$ for ribbons 10–20 nm in width). It was also shown that the GNRs have minimal defects and little edge roughness which is seen through their phase-coherent transport and their Fabry-Perot interference properties (Fig. 4).

As mentioned before, fabricating GNRs with well-ordered edges and controllable widths is an important issue for their applications in nanoscale devices. Sprinkle *et al.* reported the synthesis of self-organized GNRs on a templated SiC substrate which was prepared by using scalable photolithography and microelectronics processing.¹⁷ It was pointed out that damaging the edges of GNRs by violent cutting processes such as O_2 etching is eliminated by the contraction of top-down and bottom-up lithographies. Their results also demonstrated that the growth of graphene on non-traditional crystal faces is useful in device fabrication and for producing GNRs on a large scale.

The synthesis of large scale GNRs with high precision directly on insulating or semiconducting substrates is difficult. Jacobberger *et al.* reported the synthesis of GNRs on the Ge(001) substrate via chemical vapor deposition (CVD) technique.¹⁸ They observed that the growth of GNRs is self-aligning 3° from the Ge(110) directions, is self-defining, and

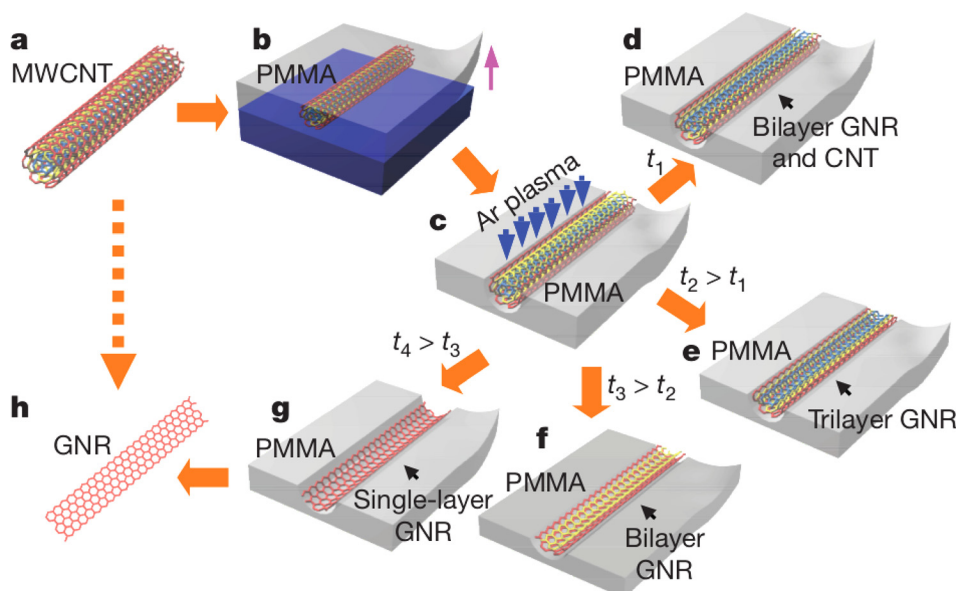


FIG. 4. The procedure of making GNRs from CNTs. (a) A pristine MWCNT, (b) the MWCNT deposited on a Si substrate, and (c) the coated PMMA-MWCNT film then peeled from the Si substrate and exposed to Ar plasma. (d)–(g) Several possible products of GNRs for different times. The PMMA was removed at the end. Reprinted with permission from Jiao *et al.*, *Nature* **458**, 877 (2009). Copyright 2009 Nature Publishing Group.

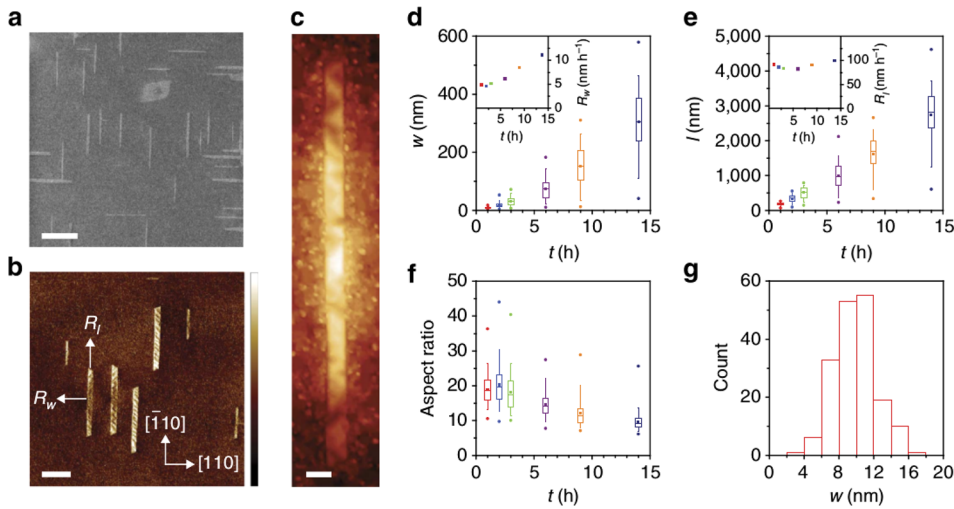


FIG. 5. Growth evolution of GNRs on Ge(001). (a) SEM, (b) AFM, and (c) STM (applied bias -2 V and current 200 pA) images. In (a) and (b), the scale bar is 400 nm and 10 nm in (c). (d) Ribbon width, w , (e) l , and (f) aspect ratio, f , plotted against time, t . Insets of (d) and (e) are the mean R_w and R_l , respectively. (g) Histogram of w from the 1 h growth in (d)–(f). Reprinted with permission from Jacobberger *et al.*, Nat. Commun. **6**, 8006 (2015). Copyright 2015 Nature Publishing Group.

has smooth armchair edges, tunable widths to <10 nm, and an aspect ratio <70 (see Fig. 5). It was mentioned that it is critical to operate in a regime in which the growth rate along the width direction is slow, <5 nm/h, in order to realize highly anisotropic ribbons on semiconducting substrates. This is an important point for the integration of GNRs into future-hybrid integrated circuits.

In addition to the synthesis of GNRs, constructing different building blocks using synthesized NRs plays a crucial role in obtaining the effect of substrate. In the study performed by Han *et al.*, self-assembly fabricated GNRs were connected end to end.¹⁹ Surface-assisted molecular assembly (SAMA) was used to synthesize and connect GNRs end to end both chemically and electronically. It was also mentioned that the Cu(111) substrate plays an important role for the molecules to form and connect the GNRs up to 50 nm long. The technique used in the study is also important for the understanding of the effect of substrate on the control of the alignment of GNRs. By using on-surface chemical reactions with an employed organo-boron precursor, they realized boron-doped graphene NRs (B-GNRs) having widths of $N=7, 14$, and 21 . Additionally, as shown by Stampfer *et al.*, two distinct voltage scales can be extracted experimentally which characterize parameter region of repressed conductance at low charge density in the ribbon.²⁰

B. Theoretical studies on graphene NRs

For the investigation of fundamental properties of GNRs, theoretical studies using analytical approaches and computational tools are of importance. By using analytical approaches such as the tight-binding method, one may be able to calculate the magnetic and electronic properties of GNRs for a large number of atoms contained in the unit cell of the structure. In contrast, computational tools based on density functional theory (DFT) can handle only relatively narrow systems with a small number of atoms in the computational unit cell. However, DFT can produce accurate results with relatively small basis sets. Another advantage of more DFT-based computational tools is that it is very efficient for the ground state calculations of fundamental structural, magnetic, electronic, and optical properties. In addition, for overcoming the limitations of DFT, many functionals and approximations can be included such as the linear scaling approach for larger systems,

lattice dynamics, and cluster expansion for investigating finite-temperature effects, and also time-dependent DFT for electronic excitations.

As mentioned before, depending on the direction of the ribbon axis, GNRs can have zigzag or armchair edges which show very different physical properties. The magnetic interaction between the edge states in a GNR was first predicted by Lee *et al.*²¹ It was found that the magnetism of edge states in GNRs can be well understood by considering the magnetic tails' interaction. At each side of the GNR, ferromagnetic (FM) interaction enhances the magnetic energy, while for the inter-edge interaction the antiferromagnetic coupling between the edge states is energetically favorable (see Fig. 6).

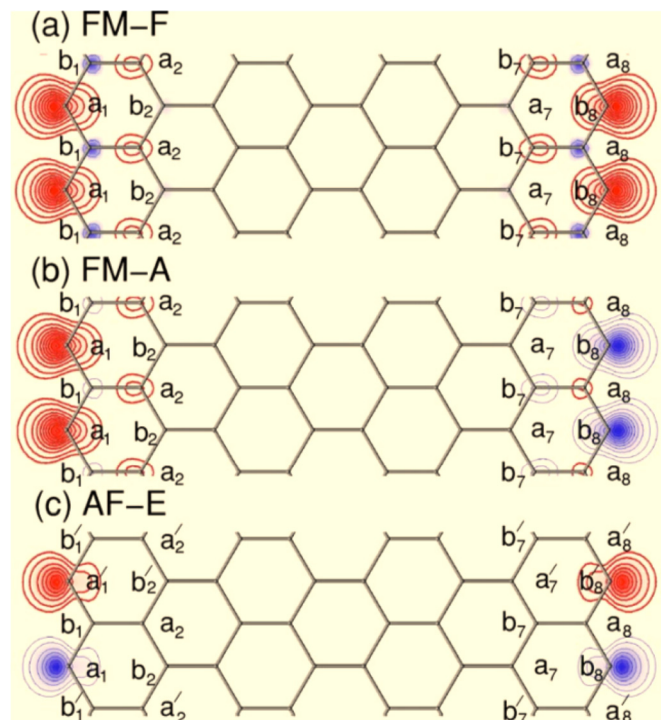


FIG. 6. Spin density contour plots for an isolated ribbon. (a), (b), and (c) are densities for FM-F, FM-A, and AF-E, respectively. Thicker lines indicate the up-spin density and thinner lines show the down-spin density. The contour plots are drawn within the plane 0.6 Å above the strip layer containing the center of carbon atoms. Reprinted with permission from Lee *et al.*, Phys. Rev. B **72**, 174431 (2005). Copyright 2005 American Physical Society.

Modification of electronic properties by external effects such as edge-functionalization or applying external electric field is necessary for the materials which are not suitable for electronic applications. Son *et al.* predicted the half-metallicity in GNRs by using first-principles calculations.²² They showed that half-metallicity is realizable under applied in-plane homogeneous electric field across the zigzag edges in GNRs. They found that the ground state of ZGNR has a bandgap which is inversely proportional to the ribbon width. In addition, they calculated an energy splitting of ~ 0.52 eV which is independent of the width of the ZGNR if $N \geq 8$. However, under applied electric field, one of the spin orientations closes its bandgap, while the other one widens it as seen Fig. 7. The study points out that the half-metallic behavior of ZGNRs can be controlled by an applied external transverse electric field. In addition, the same behavior, half-metallic character in ZGNRs, was also investigated by Kan *et al.*²³ The modification of the electronic properties of ZGNRs under functionalization of its edges by functional groups: H, NH_2 , NO_2 , and CH_3 was also investigated. It was reported that the spin-down gap becomes narrower when the ribbon width increases. Another point of the study is that some of the wide ribbons functionalized with NO_2 groups at one edge and CH_3 groups at the other edge have half-metallic character. Moreover, the half-metallic ribbons can be more stable than the H-saturated ones if the concentration of large functional groups is reduced. Son *et al.* investigated the energy bandgaps in GNRs as a function of their widths.²⁴ It was found that the origin of the bandgap in AGNRs is due to both by quantum confinement and by the crucial effect of the particular type of edges. Edge magnetization was found in ZGNRs. Those first principles calculations predict that the bandgap of AGNRs is separated into 3 families ($\Delta_{3p+1} > \Delta_{3p} > \Delta_{3p+2}$, where p is a positive integer) as a function of the ribbon width and there are no metallic NRs (Table I).

In order to realize experimental bandgap of materials, it is important to include screened Coulomb interaction

through the theoretical tools. Yang *et al.* investigated the quasiparticle energies and bandgap of GNRs by using a first-principles many-electron Green's function approach within the GW approximation.²⁵ The calculated quasiparticle bandgaps exhibit significant self-energy corrections of 0.5–3.0 eV for ribbons of width 2.4–0.4 nm for both AGNRs and ZGNRs. However, the calculated quasiparticle bandgaps are in the range of 1–3 eV for GNRs of width 2–1 nm which is promising for applications in nanoelectronics. Plasmon excitations in metallic AGNRs were studied by Shylau *et al.* and exact analytical expression for the polarization function of Dirac fermions was obtained.²⁶ At finite temperatures, the full polarization function exhibits temperature and position of the chemical potential independent behavior. Cervantes-Sodi *et al.* studied the effect of edge-functionalization and substitutional doping on the electronic and magnetic properties of GNRs.²⁷ It was reported that in ZGNRs the spin degeneracy can be broken by chemical modification. In addition, edge functionalization of AGNRs does not significantly affect the bandgap. Moreover, single-edge functionalization of ZGNRs leads to half-semiconductors with different bandgaps for each spin state and a spin-polarized half-semiconductor or a semiconductor-metal transition can be observed which are important for spin-filtering device applications. It was mentioned that high concentrations of oxygen (O) functionalization of the ribbon edges produce metallic-character ZGNRs, while for low concentration of O ZGNRs exhibit half-semiconducting behavior. In another study, Wassmann *et al.* investigated the stability, the geometry, and the electronic property of GNRs edges saturated with H atoms.²⁸ AFM ZGNRs were found to be stable only at very low ultrahigh vacuum pressures. However, for more standard conditions, mono- and di-hydrogenated structures are the most stable ones for AGNRs, while di- and two mono-hydrogenated ZGNRs are the most stable structures. It was

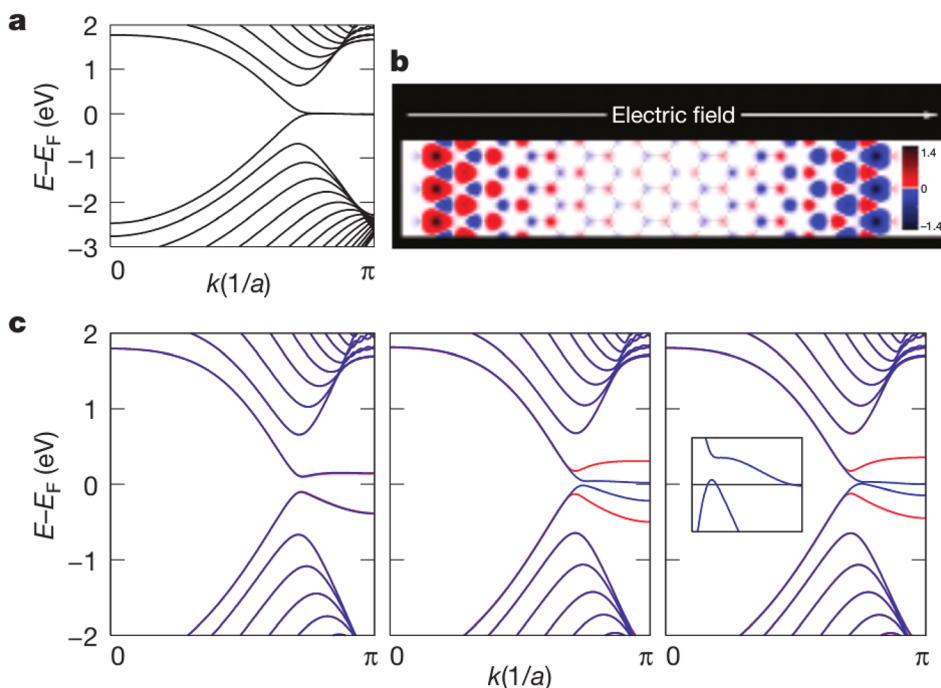


FIG. 7. (a) The spin-unpolarized band structure of 16-ZGNR, (b) the spatial distribution of the charge difference between two spin states for the ground state under zero-electric field (the scale bar is in units of $10^{-2} e/\text{\AA}^2$), and (c) the spin-resolved band structures of a 16-ZGNR under applied 0.0, 0.05, and 0.1 V/Å electric field from left to right. The red and blue lines denote two different spin-states, respectively. Reprinted with permission from Son *et al.*, Nature **444**, 347 (2006). Copyright 2006 Nature Publishing Group.

TABLE I. Synthesis technique, general electronic behavior, width dependence of electronic bandgap and magnetic ground state of recently demonstrated NRs.

| Material | References | Synthesis technique | Electronic behavior (eV) | Width-bandgap dependence | Magnetic ground state |
|-----------------------------|-------------------|---|-----------------------------------|---------------------------------|-----------------------|
| Graphene (zigzag) | 5 and 7 | Bottom-up approach | SC (1–3 eV) | | FM-AFM |
| | 9 and 10 | Rational approach | | | |
| | 11 | Anisotropic etching | | | |
| | 12 | LAO lithography | | | |
| | 14 and 15 | Unzipping MWCNTs | | | |
| Graphene (armchair) | 5, 7, and 8 | Bottom-up approach | SC (0.05–1.3 eV) | 1/w | NM |
| | 10 and 16 | Rational approach | | | |
| | 6 | SACMP | | | |
| | 11 | Anisotropic etching | | | |
| | 12 and 13 | LAO lithography | | | |
| Graphane | 37 | ... | SC | $\sim(3.42 + \exp^{-N})$ | NM |
| MoS ₂ (zigzag) | 40 | Electrochemical/chemical encapsulated in CNTs | M | w-independent | FM |
| | 42 | | | | |
| MoS ₂ (armchair) | 46 | ... | SC (0.51–0.56 eV) | Weakly dependent | NM |
| WS ₂ | 55 | Encapsulated in CNTs unzipping of WS ₂ nanotubes | SC (armchair) | Weakly dependent | NM (armchair), |
| | 56 | | (0.37–0.52 eV) M (zigzag) | | FM (zigzag) |
| ReS ₂ | 64 | CVD | SC (0.92 eV) | Very weak dependence | NM |
| TiSe ₂ | 67 | ... | SC (0.005–0.790 eV) | $\sim \exp^{-N}$ | NM |
| GaS | 70 and 71 | ... | SC (armchair) | Oscillates with w | NM (armchair) |
| | | | (1.45 eV) HM (zigzag) | | |
| ZnSe | 74 | Laser ablation of pressed-powders solvothermal procedure | SC (2.60 eV) | w-independent | ... |
| | 75 | | | | |
| SnSe | 77 | ... | SC (armchair) | Inversely proportional | NM |
| | | | (0.92 eV), M (zigzag) | | |
| TiS ₃ | 79 | Mechanical exfoliation | SC (1.0 eV) | w-independent | FM |
| ZrS ₃ | 87 and 88 | CVT | SC | ... | |
| Phosphorene | 89 | Top-down method | SC (armchair) | Inversely proportional | NM |
| | | | (0.5–0.8 eV), M (zigzag) | | |
| Silicene | 100, 101, and 104 | Deposition of Si atoms under UHV | M or SC (armchair) | Family-behavior (armchair) | NM (armchair) |
| | | | SC (zigzag) | Inversely proportional (zigzag) | AFM (zigzag) |
| Germanene | 116 | ... | SC (armchair) (0–0.9 eV) | $\sim \exp^{-N}$ | NM (armchair) |
| | | | SC (zigzag) (0.08–0.16 eV) | $\sim \exp^{-N}$ | AFM (zigzag) |
| Stanene | 120 | ... | SC (armchair) (0.05–0.35 eV) | Oscillatory-behavior | NM (armchair) |
| | | | SC (zigzag) (0.075–0.16 eV) | Inversely proportional | AFM (zigzag) |
| h-BN | 125 and 126 | Unwrapping MWBNNTs | SC (armchair), M or SC (zigzag) | | NM (armchair), |
| | | | | | NM or FM (zigzag) |
| h-AlN | 134 | ... | SC (armchair) (0.53–3.23 eV) | Monotonic-decreasing | NM |
| | | | SC, SM, or M (zigzag) (0–2.98 eV) | Monotonic-decreasing | M |

mentioned in the study that the knowledge of the structure and stability of the edges of GNRs is critical for the control of experimental conditions of GNR formation.

Determining conductance and energy scale for quantum transport properties of materials is important for their applications in atomic-scale devices. Biel *et al.* studied the quantum transport properties of chemically doped GNRs having width smaller than 4 nm.²⁹ It was found that B and N impurities in GNRs yield resonant backscattering. The features of this resonant backscattering strongly depend on the position of the dopants, the symmetry of the structure, and the width of the GNRs. In addition, they observed an unusual acceptor-donor transition in ZGNRs. In the study of Scuracchio *et al.*, the role of atomic vacancies and boundary conditions on the ballistic thermal transport properties of GNRs were investigated.³⁰ It was found that edge and central localized single atomic vacancies do not affect the low-energy transmission function of in-plane phonon modes. However, they reduce considerably the contributions of

the flexural modes. Similarly, Zhang *et al.* investigated the resonant tunneling properties of S- and U-shaped GNRs and showed that the tunneling current is tunable under varying the Fermi energy.³¹ In addition, tunability of resonant tunneling was realized by the change of width of the leads and by the lack of external gates. Petrovic and Peeters reported the existing of Fano resonances in narrow GNRs of different widths and edge types.³² In another study, Droscher *et al.* investigated the conductance of GNRs and found that single or multiple quantum dots dominate the conductance depending on the ribbon length, density of electrons, and temperature.³³ Huang *et al.* constructed a field effect transistor consisting of a metal-semiconductor-metal junction by using substitutionally doped ZGNRs.³⁴ It was shown that a metal-semiconductor transition can be seen in ZGNRs when edges are doped with B or N atoms. It was also reported that the bandgap of the doped ZGNR depends strongly on the NR width and showed a linear dependency with doping concentration. The simulated field

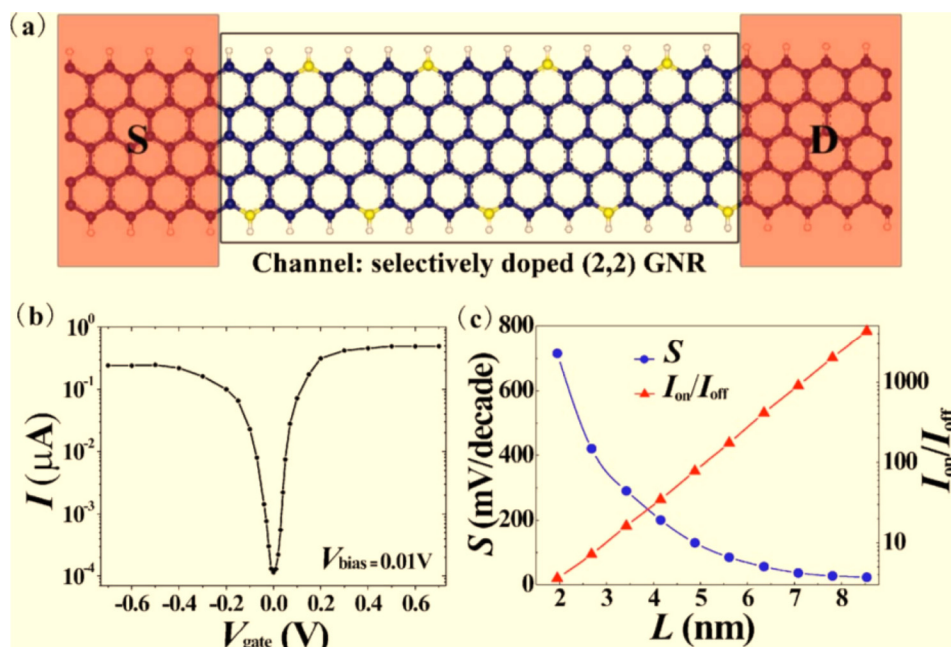


FIG. 8. (a) The schematic structure of the FET constructed from a single (2,2) ZGNR. The semiconducting region is obtained by doping the edges with N atoms (the center region). (b) Simulated I - V_{gate} curves for N-doped ZGNR-FETs under applied bias voltage of 0.01 V, the length of the channel is 8.54 nm, and the linear doping concentration is 0.1365 $1/\text{\AA}$. Reprinted with permission from Appl. Phys. Lett. **91**, 253122 (2007). Copyright 2007 AIP Publishing LLC.

effect transistor (FET) was found to exhibit excellent performance characteristics (see Fig. 8). Ren *et al.* studied electronic and elastic transport properties of AGNR-based junctions.³⁵ Their results of the I - V characteristics of various junctions demonstrate negative differential resistance (NDR) phenomena.

Full functionalization is another effective way to modify the characteristic properties of graphene-based materials. As demonstrated by Elias *et al.*, surfaces of graphene can be chemically hydrogenated.³⁶ The resulting structure, graphene, is a honeycomb structure of sp^3 linked hydrocarbons. Sahin *et al.* investigated electronic and magnetic properties of graphene NRs and found that H-passivated zigzag and armchair graphene NRs are NM semiconductors, while the bare zigzag GNRs were found to have AFM ordering at the edges.³⁷ It was shown that the bandgaps of both zigzag and armchair graphene NRs depend exponentially on the width and it decreases as the width increases.

III. NRs OF TRANSITION METAL DICHALCOGENIDES

Tremendous interest on graphene has also led to the emergence of novel two dimensional materials such as transition metal dichalcogenides (TMDs). The first synthesized member of TMDs, notably MoS_2 ,³⁸ has aroused strong interest in the field of 2D materials due to its robust chemical properties, suitable bandgap for optoelectronic applications,³⁹ and high on/off ratio of FET at room-temperature.³⁸ Different from graphene, as mentioned, 2D monolayer MoS_2 has a suitable bandgap which makes this material an important candidate for optoelectronic applications. Therefore, in the 1D NR form, the gap is tunable by its width and therefore this structure can be expected to be a promising material for technological applications.

A. NRs of MoS_2

1. Experimental studies on MoS_2

Advances in experimental techniques also opened the possibility of the synthesis of nanoscale-wide MoS_2 NRs in

various ways. For their synthesis, especially electron irradiation and CNT-based encapsulation techniques have been widely used.

The first successful synthesis of thin MoS_2 NRs was realized by performing a two-step electrochemical/chemical synthetic method, reported by Li *et al.*⁴⁰ The synthesized MoS_2 NRs were produced above 800°C (see Fig. 9) and they are 50–800 nm in width and 3–100 nm thick. The optical absorption measurements revealed that these MoS_2 NRs are direct gap semiconductors with a bandgap of 1.95 eV. It can be understood that the MoS_2 NRs with widths in the range of 50–800 nm correspond to the same electronic

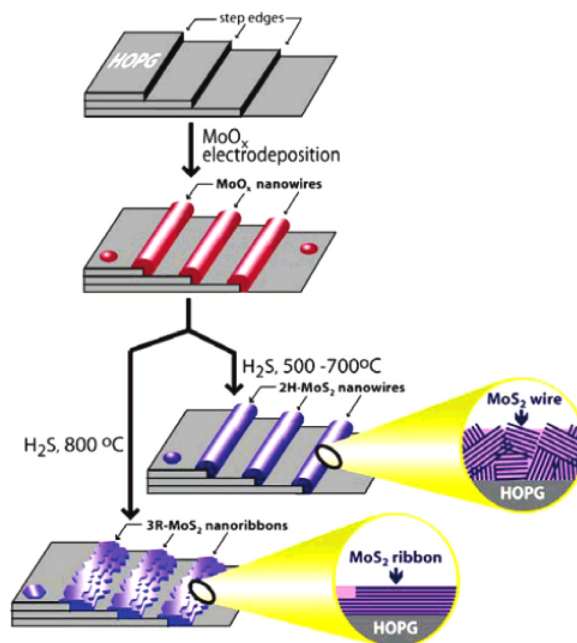


FIG. 9. The schematic representation of the electrochemical/chemical method for synthesizing polycrystalline MoS_2 nanowires and NRs on graphite surfaces. Reprinted with permission from Li *et al.*, J. Phys. Chem. B **109**, 3169 (2005). Copyright 2005 American Chemical Society.

bandgap which indicates that the bandgap is saturated to a certain value and the effect of the width of the NRs will be very small.

Electron irradiation process which uses high-energy electrons is another way of fabricating different morphologies of materials. Liu *et al.* reported the successful fabrication of MoS₂ NRs with uniform width of 0.35 nm that were formed under electron irradiation⁴¹ (see Fig. 10). It was found that the fabricated NR is a semiconductor with a bandgap of 0.77 eV and it has a Young modulus of 300 GPa. Moreover, fabricated MoS₂ NR can sustain 9% tensile strain before fracture. It was also pointed out that although it is difficult to control geometries and properties of NRs below 10 nm-width, the technique used in the study is important for such purposes.

Integrating mixed low-dimensional nanomaterials is a fascinating and challenging issue for controlling the

dimensions of the fabricated material. Wang *et al.* synthesized mixed and stable low-dimensional nanomaterial in which MoS₂ NRs are encapsulated in CNTs that they called nanoburritos.⁴² The width of the encapsulated MoS₂ NRs is uniform and is in the range of 1–4 nm, while the number of layer is down to 1–3 layers. The edge of the synthesized NRs was identified to be zigzag shape by using HRTEM which was supported by DFT calculations. It was pointed out that the synthesis technique used in the study can be extended to the synthesis of other ultranarrow TMD NRs. Transistor made of MoS₂ NR was fabricated and its physical properties were investigated by Liu *et al.*⁴³ The channel conductance in the fabricated FET was found to scale linearly with the channel width which is a signature that there is no evidence of edge damage. It was found that transistors having thin channel thickness have a larger threshold voltage (V_T). This shift is associated with the width scaling. In addition, there are

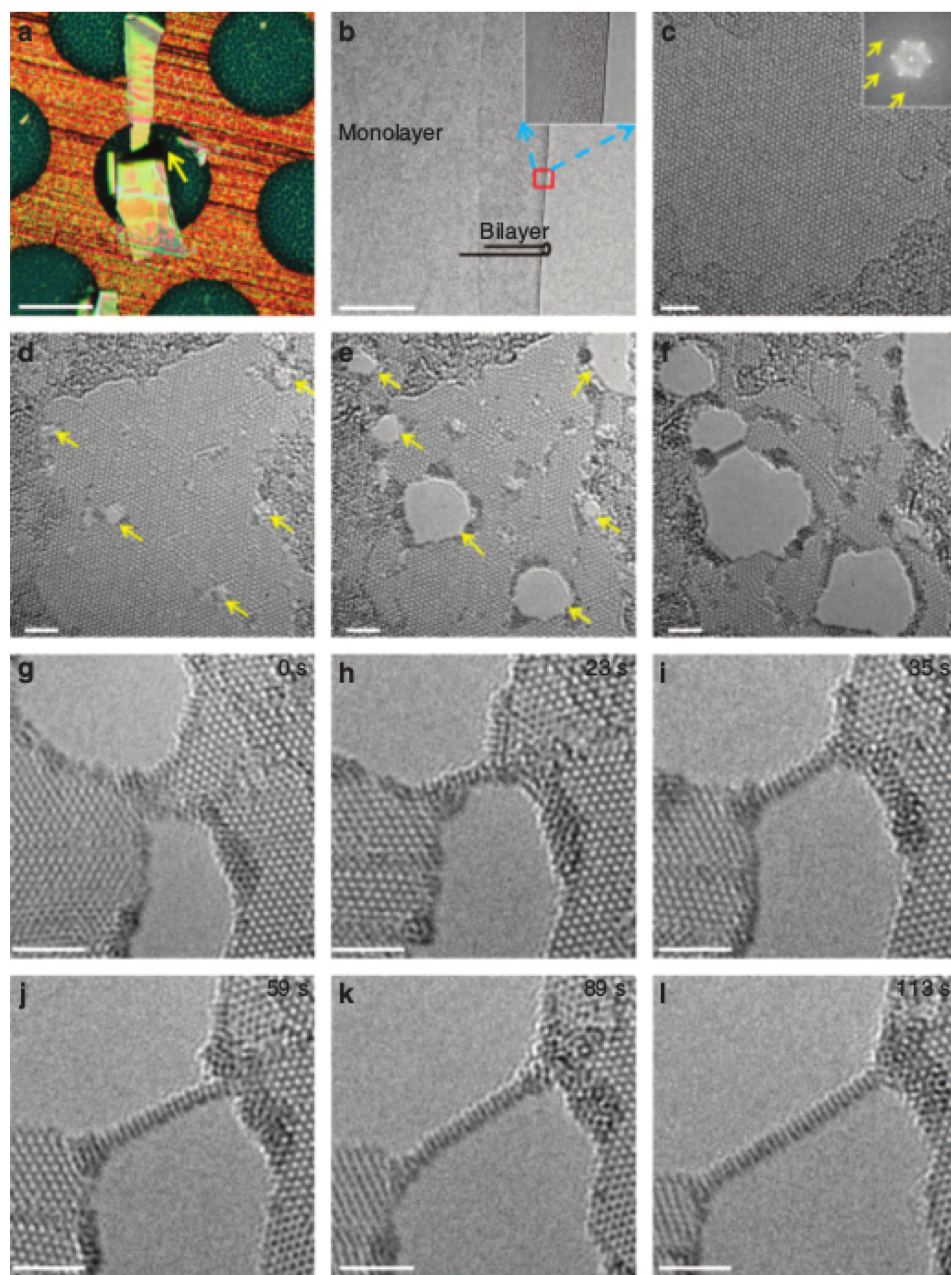


FIG. 10. (a) Few-layer MoS₂ flake on a TEM grid (scale bar is 100 μm). (b) TEM images of the thinnest region given in part (a). The straight edge reveals the single layer form of MoS₂ flake (scale bar is 100 nm). (c) HRTEM data obtained on the unfolded regions. (d) The initial MoS₂ including small irradiation-induced vacancies. (e-l) Time series of the formation of a suspended ribbon under electron irradiation (scale bar is 2 nm in c-l). Reprinted with permission from Liu *et al.*, Nat. Commun. **4**, 1776 (2013). Copyright 2013 Nature Publishing Group.

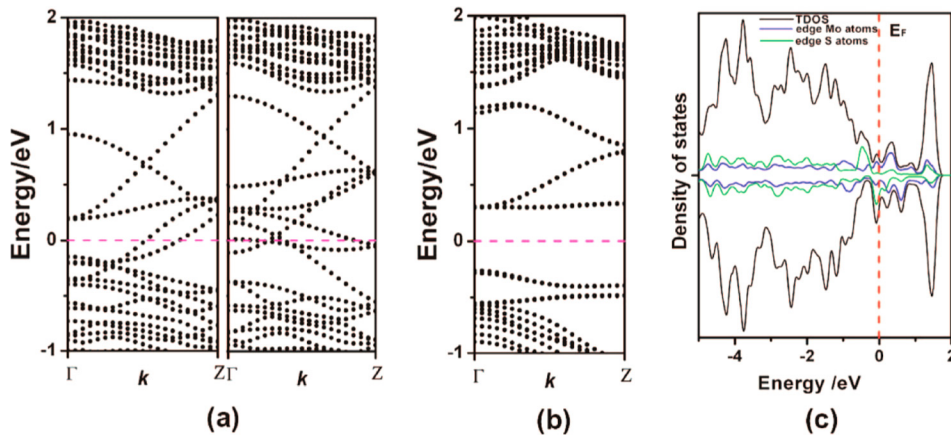


FIG. 11. (a) The spin-polarized band structure for 8-ZMoS₂ NR (left one is for spin up and right figure is for spin down states, respectively). (b) The spin-polarized band structure for 15-AMoS₂ NR. (c) Total density of states (TDOS) and local density of states (LDOS) for 8-ZMoS₂ NR (top, spin up; bottom, spin down). Reprinted with permission from Li *et al.*, J. Am. Chem. Soc. **130**, 16739 (2008). Copyright 2008 American Chemical Society.

also studies on the edge site activity of MoS₂ for hydrogen evolution reaction (HER).^{44,45} In those studies, it was mainly mentioned that the number of S edge sites plays an active role in the HER and by controlling the size of these S edge sites it is possible to engineer the HER activity in MoS₂.

2. Theoretical studies on MoS₂

Although there are only a few experimental studies on MoS₂ NRs, a much larger number of theoretical studies are available which predict the physical properties of MoS₂ NRs. Li *et al.* investigated the high stability and unusual electronic and magnetic properties of MoS₂ NRs with either zigzag (ZMoS₂) or armchair (AMoS₂) edges.⁴⁶ It was found that NRs with zigzag edges show FM and metallic behavior independent of the ribbon width and thickness as shown in Fig. 11. However, the NRs with armchair edges are NM semiconductors and the bandgap depends on the width of the ribbon and saturates to a value of 0.56 eV after a certain width of MoS₂ NR. It was also pointed out that the ZMoS₂

NRs are more stable than AMoS₂ ones and both are more stable than the reported MoS₂ nanoclusters. Ataca *et al.* studied the mechanical and electronic properties of MoS₂ NRs and also their defected structures.⁴⁷ It was predicted that the MoS₂ NRs are stiff quasi one-dimensional structures with a high in-plane stiffness. The calculated phonon frequencies for armchair MoS₂ NRs exhibit four acoustic branches as with real frequencies which indicate their dynamical stability. In addition, magnetic moments and spin-polarization of ZMoS₂ can be reduced by edge passivation with H atoms. Furthermore, NM AMoS₂ can possess a net magnetic moment depending on the adsorption site of foreign atoms and the type of vacancy defect created in the structure. The creation of MoS₂ triple vacancy in AMoS₂ results in a significant net magnetic moment of $2 \mu_B$ which is promising for magnetic applications of MoS₂ (Fig. 12).

Tuning the physical properties of materials by external fields is an important issue for using those materials in various applications. Applying external electric field and strain are two important ways to achieve such tuning. Dolui *et al.*

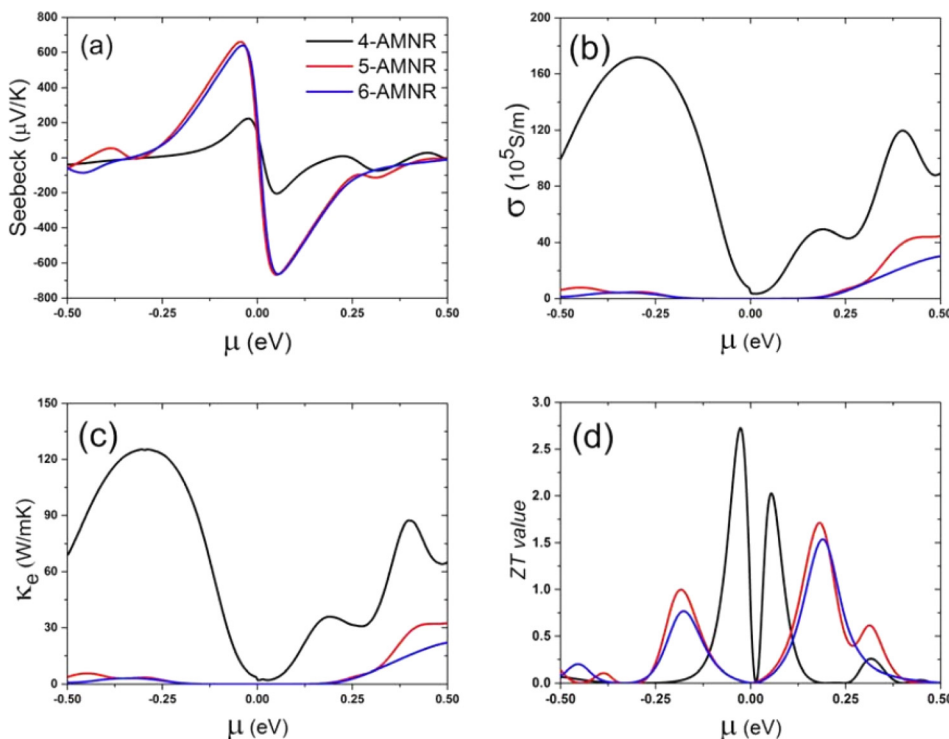


FIG. 12. The calculated electronic transport coefficients and ZT values of N-AMoS₂ NRs (N indicates the width of the NR) as a function of chemical potential at 300 K: (a) Seebeck coefficient, (b) electrical conductivity, (c) electronic thermal conductivity, and (d) ZT value. Reprinted with permission from Appl. Phys. Lett. **105**, 133113 (2014). Copyright 2014 AIP Publishing LLC.

investigated the effect of an electric field on the physical properties of AMoS₂ NRs.⁴⁸ An applied external transverse electric field was found to significantly reduce the bandgap of AMoS₂ NR and results in a metal-insulator transition beyond a certain critical field. In addition, in the case of bilayer, AMoS₂ NRs an indirect to direct gap transition is induced by the applied field. The critical electric field decreases with increasing ribbon width. Ouyang *et al.* studied the effect of hydrogenation of AMoS₂ NRs in terms of edge magnetization and reported that bare and fully passivated AMoS₂ NRs are NM semiconductors but FM edge states can be induced by patterned hydrogenation.⁴⁹ In addition, in the presence of an applied transverse electric field, partial edge hydrogenation can change a small size AMoS₂ NR from semiconductor to metal or semimetal. Thus, hydrogenation is an important way to tune the magnetic and electronic properties of AMoS₂ NRs.

The possible battery capacity of MoS₂ NRs was investigated for different types of atoms. Yang *et al.* studied the ZMoS₂ NRs as a promising cathode material for rechargeable Mg batteries by first-principles calculations.⁵⁰ By calculating the possible adsorption sites and diffusion kinetics for Mg atom on ZMoS₂ NR, they found that the top of the Mo site at the edge of the NR is the most favorable site for Mg atom. In addition, a maximum theoretical capacity of 223.2 mA h/g was predicted for double site Mg adsorption case. The activation barrier for a Mg atom to diffuse between the two Mo-top sites was calculated to be only 0.48 eV. It was pointed out in this study that in terms of its Mg storage capacity and diffusion kinetics, ZMoS₂ NRs can be a good candidate for rechargeable Mg batteries. Li *et al.* investigated the adsorption and diffusion of Li atoms on ZMoS₂ NRs for possible applications in Li-ion batteries.⁵¹ It was reported that going from MoS₂ nanosheets to ZMoS₂ NRs, the binding energy and the mobility of Li atoms increase which makes the ZMoS₂ NR a promising cathode materials for Li-ion batteries with high power densities and fast charge/discharge rates.

The thermoelectric properties of AMoS₂ NRs were investigated by Fan *et al.*⁵² AMoS₂ NRs could be optimized to exhibit very good thermoelectric performance. The figure of merit (ZT) value of the considered NRs was found to be width dependent and can take values as high as 2.7 at room temperature. It was pointed out that if the width or edge of the synthesized NR can be controlled, then AMoS₂ NRs could become very promising thermoelectric materials. Zhang *et al.* investigated the phonon thermal conductivity in MoS₂ NRs and found that in contrast to GNRs, the thermal conductivity of MoS₂ NRs is insensitive to the width, the length, and the type of NR edge.⁵³ In addition, Liu *et al.* studied the anisotropic thermal conductivity of MoS₂ NRs in a more general manner.⁵⁴ Since the previous thermal transport studies were limited to zigzag and armchair directions only, they investigated anisotropic thermal transport properties of MoS₂ NRs in different directions and reported that thermal conductivity has a local maximum at the direction of 19.1°. Furthermore, calculated full-band phonon dispersion revealed that over 90% of the thermal conductivity is contributed by the LA mode in MoS₂ NRs.

B. NRs of WS₂

Tungsten disulfide (WS₂), a member of the TMD family, possesses a layered structure in its bulk form which is quite similar to MoS₂. WS₂ mainly exhibits the properties of dry lubricants and it was used in conjunction with other materials as catalyst for hydrotreating of crude oil. In addition, it can also be used in high temperature and high pressure applications. Similar to MoS₂, when thinned down to its monolayer form, an indirect-to-direct optical transition was observed. The monolayer form of WS₂ was also successfully isolated.

The 1D NR form of WS₂ was first synthesized by Wang *et al.* as encapsulated in CNTs.⁵⁵ Single and double walls CNTs were used as templates and successfully fabricated WS₂ NRs were realized with smooth edges. The reported widths of the WS₂ NRs vary between 1 and 2 nm and the number of layers is 1–3 depending on the diameter of the CNTs. It was found that in contrast to bulk WS₂ which has a NM semiconducting ground state, whereas free standing ultra-narrow zigzag WS₂ NRs can have magnetic or NM metallic ground state depending on the edge passivation. However, the WS₂ NRs with armchair edges always remain NM semiconductors having a narrow gap. In another study, Nethravathi *et al.* synthesized WS₂ NRs by chemically unzipping WS₂ nanotubes using Li atoms.⁵⁶ WS₂ nanotubes were intercalated by Li atoms and the nanotubes reacted with various solvents and broke into NR pieces. The synthesized NRs are about 10–12 layers and have a width of about 100 nm which is wider than that synthesized by Wang *et al.*⁵⁵

There exist several theoretical studies by investigating the physical properties of these NRs which we will summarize now in this part of the review. Zhang *et al.* investigated the structural, electronic, and magnetic properties of WS₂ NRs and found that the properties of the NRs are strongly affected by the type of the edges.⁵⁷ Armchair-edged WS₂ NRs are NM semiconductors, while the zigzag-edged ones are magnetic metallic structures. In addition, it was shown that the electronic and magnetic properties of WS₂ NRs are, respectively, sensitive to external electric field and applied strain. Ouyang *et al.* studied the effect of edge hydrogenation on the physical properties of WS₂ NRs.⁵⁸ It was found that zigzag WS₂ NRs conserve its FM semiconducting behavior upon edge hydrogenation, while WS₂ NRs with armchair edges convert from NM to magnetic ground state when at least one edge is partially hydrogenated. Furthermore, it was found that depending on the width of WS₂ NRs, magnetic moment of zigzag WS₂ NRs displays periodic behavior.

In addition to their fundamental physical properties, the chemical activity of WS₂ NRs was theoretically investigated by considering their interactions with certain molecules. Kvashnin *et al.*⁵⁹ studied the interaction of 1-octanethiol molecule with Li ions to simulate the experiment performed by Nethravathi *et al.* It was found that unzipping WS₂ nanotubes occurs due to the intercalation of lithiated multi wall nanotubes by 1-octanethiol molecules. Since the lithiated nanotubes expand, unzipping is possible with 1-octanethiol molecule. It was shown that the penetration of this molecule

between walls of the nanotube stretches the nanotube up to an amount of 8.9% which enables the unzipping of the nanotube to obtain WS₂ NRs. In another theoretical study, Lopez-Urias *et al.* investigated the electronic, magnetic, optical, and edge reactivity properties of WS₂ NRs.⁶⁰ They showed that zigzag-edged WS₂ NRs exhibit a FM metallic ground state with magnetic moments localized at the W and S edge atoms. The NRs with armchair edges display semiconducting behavior. It was also reported that there is a strong optical polarization anisotropy which enhances a well defined absorption intensity peak having a polarization along the axis of the NR. The reactivity of the edges of WS₂ NRs was tested by making the edges interact with molecules. Results demonstrated that water molecule at the armchair edge dissociates into OH attached to a W atom and the H which is attached to the S atom on the edge.

C. In-plane-anisotropic NRs: ReX₂s

In a single crystal, the physical properties often differ with the crystallographic orientation and these materials are known as anisotropic materials. Monolayer crystals of these in-plane anisotropic materials are another subclass of dichalcogenides. Due to their orientation dependent electronic, magnetic, optical, and thermal properties, there are many application areas for these anisotropic materials. From the family of TMDs, monolayer ReS₂ has been recently synthesized and gained a lot of interest owing to its distorted and anisotropic structure.⁶¹ It was reported that this new monolayer material behaves as its bulk form both electronically and vibrationally. It was shown that when ReS₂ is thinned from bulk to monolayer, it still remains as a direct bandgap semiconductor and its Raman spectrum shows no dependence on the number of layers. ReSe₂, another member of TMDs family which has also a distorted crystal structure like ReS₂, has been successfully synthesized in its monolayer form.⁶² It was found that the fabricated FET with monolayer ReSe₂ exhibits p-type conductivity at room temperature with a higher mobility than that of the few-layered one. In addition, it was reported that the number of layers strongly affects the band-gap and mobility in ReSe₂.

Although its 2D monolayer form was synthesized and its physical properties were analyzed, 1D NR form of ReSe₂ has not been synthesized yet. However for quasi-1D structure of ReSe₂, the response of optical, electrical, and magnetic properties to external stain was investigated by Yang *et al.*⁶³ Nanoscale local strain can modulate the optical bandgap, induce magnetism, and change the electronic and vibrational response of ReSe₂ before the fracture point.

The NR form of ReS₂ was successfully synthesized by He *et al.*⁶⁴ The direct growth of high-quality ReS₂ layers and NRs by the CVD method was reported. It was found that by tuning the growing time for ReS₂ layers, ReS₂ NRs can be synthesized (see Fig. 13). It was pointed out that controlling the growth time for ReS₂ different morphologies of the material can be synthesized.

In addition to this experimental study, there are also theoretical investigations on the electronic properties of ReS₂ NRs. Yu *et al.* investigated the effect of ribbon width on the

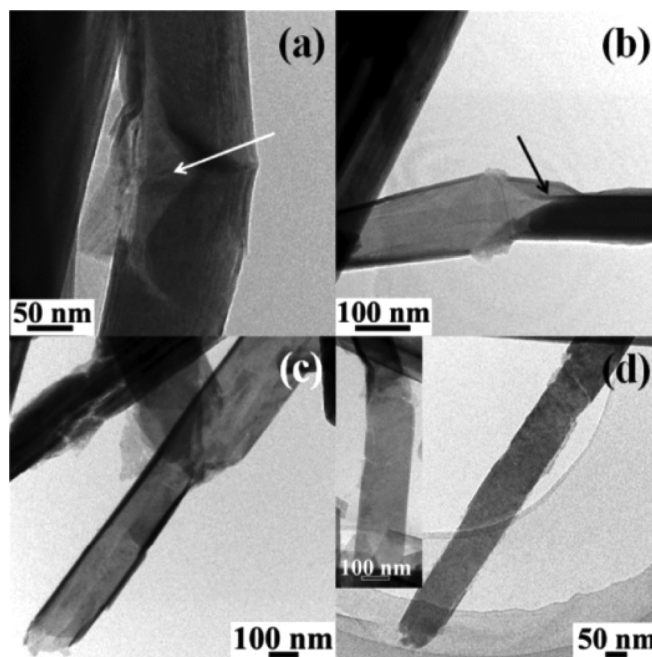


FIG. 13. (a)–(d) Bright-field TEM images of WS₂ NRs which are produced by unzipping of lithiated WS₂ NTs with the help of octanethiol. (a) and (b) demonstrate the incubation stages for the unzipping process. Reprinted with permission from Nethravathi *et al.*, ACS Nano 7, 7311 (2013). Copyright 2013 American Chemical Society.

electronic properties of ReS₂ NRs.⁶⁵ They showed that the direct bandgap of ReS₂ NRs depends very weakly on the width of the NR and after a certain width the bandgap saturates to a value of 0.92 eV. It was pointed out that when compared with other TMDs members, the reduction in the bandgap of monolayer ReS₂ when thinned to NR form is smaller (Fig. 14).

D. Octahedrally coordinated NRs: TiSe₂

As mentioned before, TMDs can possess 1H or 1T symmetry in their ground state depending on the constituent atoms. As a member of 1T-TMDs family, TiSe₂ is an intrinsically layered material in its bulk form which possesses both superconducting and charge density wave (CDW) ordering and thus, it has been widely studied due to these remarkable physical properties.

The monolayer form of this material was first synthesized by Peng *et al.* by molecular beam epitaxy (MBE) growth on SiC(0001) substrate.⁶⁶ Upon growing monolayer TiSe₂ crystals, two different types of defects were observed: interstitial and Se vacancy. It was shown that the concentration of these defects depends critically on the substrate temperature. In addition, it was reported that the band structure of monolayer TiSe₂ differs fundamentally from its bulk counterpart.

The NR structure of TiSe₂ was proposed theoretically; however, it has not been synthesized yet. Ozaydin *et al.* investigated the electronic and magnetic properties of 1T phase of TiSe₂ NRs (1T-TiSe₂ NRs) which is a member of TMDs family.⁶⁷ The electronic bandgap of the 1T-TiSe₂ NRs decreases exponentially as the width of the ribbon gets wider over 20 Å. In addition, for ultranarrow zigzag edge

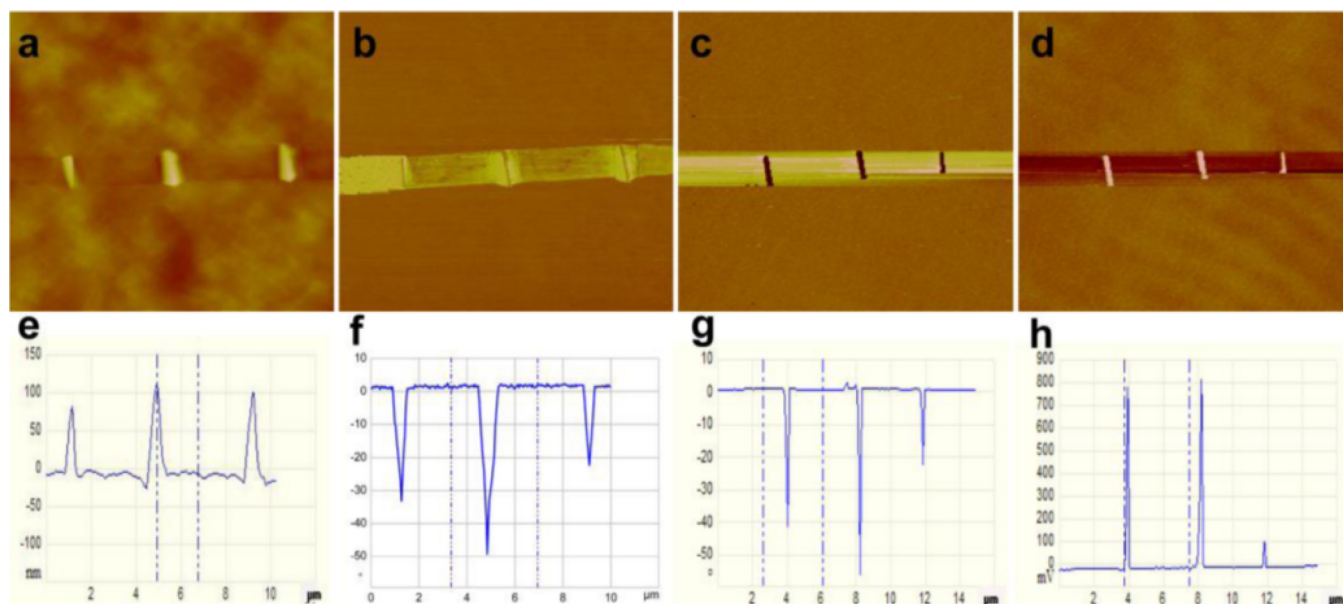


FIG. 14. Magnetic force microscopy (MFM) measurements of quasi-1D ReSe₂. (a) AFM topography, (b) phase, (c) MFM phase, and (d) MFM amplitude for wrinkled flakes on gel-film substrate. (e)–(h) The profiles for images in (a)–(d). Reprinted with permission from Yang *et al.*, *Nano Lett.* **15**, 1660 (2015). Copyright 2015 American Chemical Society.

1T-TiSe₂ NRs, odd-even oscillations were shown. Calculations on the magnetic properties demonstrated that all 1T-TiSe₂ NRs, even zigzag or armchair edged, have non-magnetic ground states.

IV. MONOCHALCOGENIDE NRs

In addition to TMDs, compounds having monochalcogenide atom in their chemical formula have been the focus of recent interest due to their potential applications in various fields. These materials can be classified into different sub-classes depending on the non-chalcogenide atom in the structure. For instance, crystals with Ge, Sn, or Pb atoms correspond to group IV mono-chalcogenide family, while structures with Ga or In atoms stand for post-transition metal mono-chalcogenide (PTMC) family. Some of these crystals have layered bulk structures and like many other layered materials, when dimensional reduction is achieved they possess different physical properties.

A. Gallium monochalcogenides: GaS, GaSe

Gallium sulfide (GaS) and gallium selenide (GaSe) are two members of PTMC and have a layered crystal structure in their bulk forms. The 2D monolayer forms of these PTMC structures were successfully synthesized and gained a lot of interest due to their unique physical properties. Meng *et al.* presented a functionalization technique to control the optical properties of both CVD grown and exfoliated Ga-based PTMCs using pyridine (C₅H₅N) organic intercalant molecules.⁶⁸ It was found that the molecules intercalate between GaSe layers and cause an increase in PL intensity of the crystal. In another study, Cai *et al.* built a type-I Ga-chalcogenide heterojunction by transferring exfoliated few-layer GaSe onto bulk gallium telluride (GaTe) sheets.⁶⁹ It was reported that GaSe layers provide photo-excited electrons

and holes to the GaTe sheets transferring from outer layers to the interface. It was pointed out that the optical performance of the heterostructure can be tuned by combining different thicknesses of the Ga-chalcogenide layers.

Although its nanowire, nanotube, and nanobelt forms were synthesized, NRs of GaS crystal have not been synthesized, so far. However, there are theoretical studies predicting some unique properties of the NR form of GaS. Wang *et al.* investigated the electronic properties and edge effects of GaS NRs and found that the electronic properties of the GaS NRs are strongly affected by the edge structure.⁷⁰ Zigzag-edged GaS NRs are metallic with spin-polarized edges independent of the H passivation, while the armchair-edged GaS NRs display indirect-gap semiconducting behavior. It was shown that for armchair NRs the bandgap oscillates as the width of the NR increases and saturates to a constant value for wide NRs. Additionally, Zhou *et al.* investigated the intrinsic half-metallic character with FM coupling in GaS NRs.⁷¹ They demonstrated that this magnetic property occurs at the Ga-dominated edge of GaS NRs due to *p* states of S and *s* and *p* states of Ga atoms. Moreover, it was shown that this novel half-metallic behavior with FM coupling is rather robust especially for GaS NRs with large width and thickness. It is important to note that half-metallic behavior with FM coupling can be induced in GaS NRs without any external effects such as an external electric field or applying strain.

B. Mono-selenide NRs: ZnSe and SnSe

ZnSe, another material containing chalcogenide atom, is a member of group II-VI semiconductors and its 1D structures, ZnSe NRs, were recently synthesized.^{72,73} Jiang *et al.* successfully produced ZnSe NRs using laser ablation of ZnSe pressed-powders.⁷⁴ Their experiments on the characterization of ZnSe-NRs revealed that it has a perfect

wurtzite-2H single-crystal structure. In addition, micro-Raman scattering analysis showed that both the longitudinal optic (LO) and the transverse optic (TO) phonon peaks of the ZnSe NRs are shifted toward low frequencies relative to its bulk values due to small-size and the large-surface effects. It was also pointed out that this synthesis technique can be useful for the synthesis of other II–VI non-oxide semiconductor NRs. Later in another study, Zhao *et al.* fabricated vertically aligned ZnSe-NR arrays.⁷⁵ The ZnSe-NRs were grown on a Zn foil by using a simple solvothermal procedure. It was reported that the synthesized NRs are 100–300 nm in width and about 4 nm in thickness, while their lengths are about 2 μm . Their results demonstrated that the ZnSe-NRs are good field emitters when compared with many other nanostructures with a low turn-on field of 5 V/ μm .

SnSe is another crystal of chalcogenide based materials. Its 2D structure was recently synthesized as a new member of the transition metal chalcogenide (TMC) family. Li *et al.* successfully synthesized the single-layer single-crystalline SnSe nanosheet with thickness of about 1.0 nm.⁷⁶ One-pot solution method was used to prepare single-crystalline SnSe and it was reported that 1,10-phenanthroline (Phen) plays an important role in determining the morphology of the SnSe because in the absence of Phen three-dimensional SnSe nanoflowers were obtained although all other parameters are the same.

The 1D form of this material was also considered theoretically (see Fig. 15). Huang *et al.* investigated the edge-, width-, and strain-dependent electronic properties of SnSe NRs and found that electronic properties can be tuned by: (i) altering the width parameter, (ii) applying tensile or compressive strain in zigzag SnSe NRs, and (iii) modification of edge type.⁷⁷ In addition, they found that semiconductor-metal or metal-semiconductor transition can be realized by controlling all these parameters. Tyagi *et al.* studied the thermoelectric properties of SnSe NRs.⁷⁸ It was found that armchair NRs with widths less than 47 Å display semiconducting character, while the zigzag-edged NRs narrower than 52 Å are metallic. For the armchair SnSe NRs with 6 Å width, a relatively high

Seebeck coefficient (SC) of 1720 $\mu\text{V}/\text{K}$ and a low thermal conductivity were reported. It was pointed out that SnSe NRs may provide thermoelectric performance similar to that of monolayer and low-temperature bulk phases of SnSe.

V. NRs OF TRI-CHALCOGENIDES

Like the TMD family, transition metal trichalcogenides (TMTs) exhibit layered structures with weak interlayer van der Waals interactions in their bulk form. Bulk TMTs having the formula of MX_3 ($\text{M} = \text{Ti}, \text{Zr}, \text{Hf}; \text{X} = \text{S}, \text{Se}, \text{Te}$) have been widely studied for several decades. However, only the 2D monolayer form of titanium three sulfide (TiS_3) was successfully isolated and reported to be a direct gap semiconductor. Before its successful isolation of 2D monolayer form, 1D NR of TiS_3 was synthesized.

A. High electron mobility NRs: TiS_3

One of the most recently announced NR structure is TiS_3 that belongs to the trichalcogenides. Island *et al.* first isolated few-layer TiS_3 NRs that were used to fabricate FET.^{79,80} The fabricated devices show an ultrahigh photoresponse up to values of 2910 A/W. In addition, an n-type semiconducting behavior with mobilities of 2.6 $\text{cm}^2/\text{V s}$ and on/off ratio of 10^4 was found for TiS_3 NRs which make it an interesting material for photodetection and photovoltaic applications. NRs of TiS_3 were also successfully synthesized by Barawi *et al.*⁸¹ The hydrogen storage capacity of TiS_3 NRs was studied. The stability of TiS_3 NRs was investigated by TGA (thermal gravimetric analysis) measurements which were carried out under argon and it was found that TiS_3 NRs are stable below 400 °C. It was also found that the amount of the stored H increases as the H_2 pressure increases up to 80 bars. In another study, Pawbake *et al.* carried out temperature-dependent Raman spectroscopy of TiS_3 NRs and compared it with that of TiS_3 nanosheets.⁸² The Raman modes soften (red shift) as the temperature increases from 88 to 570 K which is related to the anharmonic vibrations of the lattice. This property can be an important mark in determining the temperature of TiS_3 nanodevices by using Raman spectroscopy. It was also pointed out that the Raman modes of TiS_3 NRs are less sensitive to temperature than that of TiS_3 nanosheets which is related to lower interlayer coupling in the nanosheets. Another successful synthesis of TiS_3 NRs was achieved by Cui *et al.* and the time-resolved transient absorption measurements on TiS_3 NRs were reported⁸³ (see Fig. 16). It was found that time-resolved measurements reveal ultrafast injection, the thermalization, energy relaxation, and exciton formation of photocarriers occur on a subpicosecond time scale.

Although experimental studies on chalcogenide based NRs are limited, theoretical studies report the physical properties of these structures. Here, we review some of these important studies.

As mentioned above TiS_3 was first successfully synthesized in NR form. After that, theoretical analyses of this structure were provided. Kang *et al.* studied the electronic properties, carrier mobility, and strain response of TiS_3 NRs and found that the edge type of the NR strongly affects the

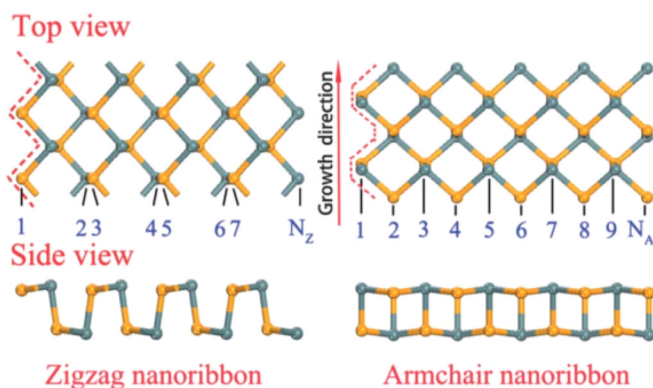


FIG. 15. Structures of SnSe NRs for zigzag (left panel) and armchair (right panel) and the definitions of the width parameters. Reprinted with permission from Huang *et al.*, RSC Adv. **4**, 6933 (2014). Copyright 2014 Royal Society of Chemistry.

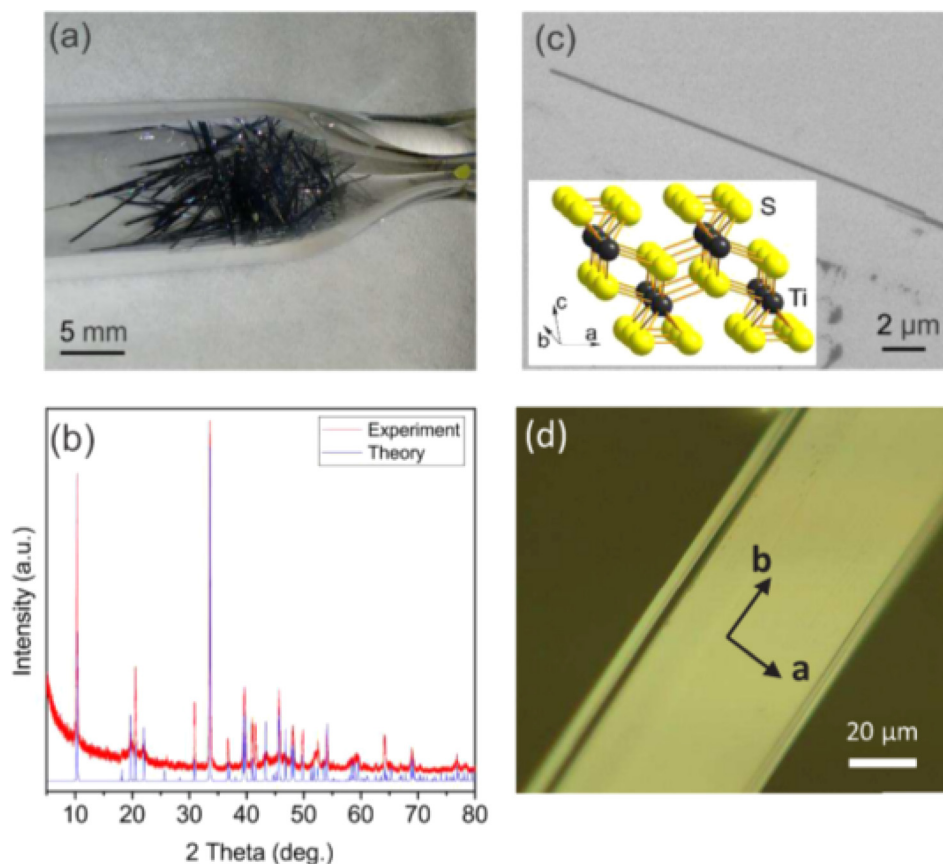


FIG. 16. Synthesis and characterization of TiS_3 crystals. (a) An image of TiS_3 single crystal formed on the walls of a quartz ampoule. (b) Corresponding powder X-ray diffraction pattern obtained both experimentally (red) and theoretically (blue). (c) SEM image of exfoliated TiS_3 crystal on Si/SiO_2 substrate. The inset demonstrates the crystal structure of TiS_3 with labelling crystallographic directions. (d) Optical microscopy image of a TiS_3 NR. Reprinted with permission from Cui *et al.*, ACS Appl. Mater. Interfaces **8**, 18334 (2016). Copyright 2016 American Chemical Society.

electronic properties.⁸⁴ Depending on the edge type, TiS_3 NRs can display metallic or semiconducting behavior which is independent of the ribbon width. This was reported as an important point because in an experiment there can exist NRs with different widths on the same substrate and all these ribbons will have the same electronic bandgap. In addition, it was reported that upon passivation of the edges of NRs by H atoms, the bandgap of semiconducting TiS_3 NRs is significantly increased. Furthermore, it was shown that the bandgap increases as the applied tensile strain is increased, demonstrating a direct-to-indirect bandgap transition.

B. Quasi-1D behavior in ZrS_3

Zirconium trisulfide (ZrS_3), a member of the TMT family, is also a typical van der Waals (vdW) stacked layered material in its bulk form and can be isolated to its 2D monolayer form as many other layered materials. Although its 2D monolayer structure has not been synthesized yet, there are several theoretical studies that predict and investigate the physical properties of 2D monolayer ZrS_3 . Jin *et al.* predicted the possibility for exfoliation of monolayer ZrS_3 from its bulk form by calculating the cleavage energy.⁸⁵ It was shown that low cleavage energy of ZrS_3 favors a stable exfoliated monolayer structure. In addition, electronic-band structure calculations revealed that monolayer ZrS_3 is an indirect-gap semiconductor with a bandgap of 1.90 eV. Moreover, it was reported that like other monolayer TMT, ZrS_3 exhibits anisotropic conduction properties which were demonstrated by calculating the electron and hole effective masses. Li *et al.* studied the tunable electronic properties of

TMTs family including monolayer ZrS_3 .⁸⁶ It was found that monolayer ZrS_3 can undergo an indirect-to-direct bandgap transition as a function of applied tensile strain ($\epsilon = 2\%$). It was also pointed out that this tunable electronic structure provides opportunities for designing structures for applications in optoelectronics and flexible electronics.

Although its 1D NR form has not been synthesized yet, quasi-1D crystal of ZrS_3 has been studied. Osada *et al.* investigated the phonon properties of few-layer quasi-1D form of ZrS_3 .⁸⁷ A considerable downshift of the frequency of the A_g^3 mode with decreasing number of layers and a slight downshift of the A_g^5 mode were found which were explained through intrachain, interchain, and interlayer force constants using simple 1D lattice models. Thus, it was pointed out that the large shift of the A_g^3 mode reflects the quasi-1D structure of ZrS_3 . Very recently, Pant *et al.* studied the strong dichroic emission in quasi-1D ZrS_3 and found that the optical properties of few-layer ZrS_3 are highly anisotropic as revealed by PL intensity variation with the direction of polarization.⁸⁸ It was pointed out that this observed PL variation with polarization has a strong similarity with conventional 1D materials with the difference that these 1D chains interact with each other in this structure.

VI. BLACKPHOSPHORUS NRs (bpNRs)

Blackphosphorus, which was recently synthesized as a new member of the class of 2D materials, exhibits unique physical properties due to its anisotropic and puckered structure. Das *et al.* demonstrated the formation of few-nanometer-wide BPNRs with both zigzag and armchair edges with

controlled structural modification of few layer blackphosphorus.⁸⁹ Using a top-down method, it is possible to fabricate NR from suspended few-layer blackphosphorus flakes. The fabricated BPNRs were about 10 nm on width and few layers on thickness.

Even though the experimental studies on BPNRs are very limited, there are already important theoretical studies that analyze their physical properties. Zhang *et al.* studied the electronic properties of BPNRs having different widths and edge configurations and reported that BPNRs with armchair edges are semiconductors, while the zigzag BPNRs are metallic.⁹⁰ For armchair BPNRs, it was shown that the bandgap decreases as the width of the NR increases. After H-passivation of the edges, zigzag BPNRs become semiconducting, while the bandgap of the armchair BPNR gets larger than for bulk phosphorene. In addition, it was demonstrated that all the semiconducting NRs exhibit very large values of Seebeck coefficient (SC) and are tunable upon hydrogen passivation of the edges. Ding *et al.* also investigated the effect of edge passivation on the electronic structure of BPNRs.⁹¹ The edges of BPNRs are highly active and can be bonded easily with oxygen atoms and hydroxyl groups demonstrating that BPNRs can be easily oxidized. In addition, it was shown that a transition from semimetallic character to semiconducting can be achieved in both zigzag and armchair BPNRs upon oxidation.

Localized surface plasmon resonance (LSPR) is an optical phenomenon generated by light when it interacts with conductive smaller particles than the wavelength of incident light. Liu and Aydin investigated LSPR in monolayer of BPNRs and LSPR at mid-infrared and far-infrared wavelength regimes was demonstrated.⁹² It was shown that due to the strong anisotropic in-plane properties, BPNRs can display polarization dependent anisotropic plasmonic response.

In another study, Sorkin and Zhang investigated the mechanical properties BPNRs under uniaxial tensile strain and reported that the deformation and failure of BPNRs are highly anisotropic.⁹³ It was reported that BPNRs have a high failure strain ($\varepsilon=0.5$) along the armchair direction with a low failure stress ($\sigma=50$ GPa), while along the zigzag direction the failure occurs at early stages of tensile strain ($\varepsilon=0.1$) but with a relatively high failure stress ($\sigma=100$ GPa). For both directions, the value of the failure stress is sensitive to the width of the BPNRs, while the failure strain is unaffected.

VII. GROUP IV NRs

The first synthesized 2D material is known as graphene which consists of C atoms that belong to the IV member in periodic table. After successful isolation of graphene from its bulk counterpart, graphite, researchers started to search for other group IV atoms that are able to form a 2D structure. Monolayer crystals of silicon, namely, silicene, germanene, and stanene, were first predicted theoretically to be buckled stable monolayers and then successfully synthesized on different substrates.^{94–99} Due to the same structural properties with graphene, these monolayers exhibit similar electronic

properties with those of graphene such as possessing Dirac cone and thus, dimensional reduction in these materials gained a lot of interest as in the case of other 2D materials.

A. GNRs' cousin: Silicene NRs

Silicene, a 2D honeycomb structure of Si atoms with a buckled geometry, has been attracting great interest due to its physical properties such as possessing massless Dirac fermions and large spin-orbit coupling resulting in an intrinsic bandgap. 1D NRs of silicene have been also successfully synthesized.

Production of silicon NRs (SiNRs) on different substrates was performed in various experiments. In one of them, De Padova *et al.* synthesized silicon NRs (SiNRs) by depositing Si atoms on silver (110) surface under UHV conditions.^{100,101} The synthesized NRs have lengths of nanometers and about 1.6 nm of width with just 0.2 nm of height. High-resolution synchrotron radiation photoelectron spectroscopy measurements demonstrate a strong metallic character in these SiNRs. DFT calculations showed that NRs have a silicene like honeycomb structure on the silver substrate. Tchalala *et al.* experimentally observed self-assembled SiNRs on Au(110)- 2×1 reconstructed surface.¹⁰² Low electron energy diffraction (LEED) showed a new superstructure which corresponds to SiNRs observed upon adsorption of Si atoms on Au(110) surface. STM and high-resolution photoemission spectroscopy measurements demonstrated that these SiNRs are flat and have widths of 1.6 nm. These NRs show very similar structural properties with the ones synthesized on Ag(110) surface. De Padova *et al.* successfully synthesized multilayer of SiNRs on Ag(110) surface.¹⁰³ It was shown by angle-resolved photoemission spectroscopy (ARPES) that the synthesized SiNRs have a gap of 0.56 eV centered at 0.62 eV below the Fermi level which differs from the one-atom-thick structure. The SiNRs were formed to have zigzag edges with hexagon apexes aligned along their lengths. Feng *et al.*¹⁰⁴ recently studied the structure and quantum well states (QWS) in silicene NRs (SiNRs) which were grown on Ag(110) surface as performed by De Padova *et al.* (see Figs. 17–19). The structure of the synthesized SiNRs has a reconstructed armchair shape. Depending on the temperature, the width of the SiNRs can be 1 nm or 2 nm with increasing lengths. Pronounced quantum well states (QWS) were observed in SiNRs due to the confinement of quasiparticles perpendicular to the NR. The origin of QWS arises from the metallic states of SiNRs and was found to be substrate-independent.

Stiffness or flexibility of a material can be determined through its mechanical parameters. Topsakal and Ciraci investigated the mechanical properties of SiNRs in both elastic and plastic regimes under applied uniaxial tension.¹⁰⁵ It was shown that the electronic and magnetic structures of SiNRs are very sensitive to the applied uniaxial strain. The calculated in-plane stiffness is about 51 N/m which is very small compared with that of GNRs (292 N/m) which indicates the larger flexibility of the SiNRs. Jing *et al.* investigated the mechanical properties of SiNRs under uniaxial tension and found that the Young modulus is strongly

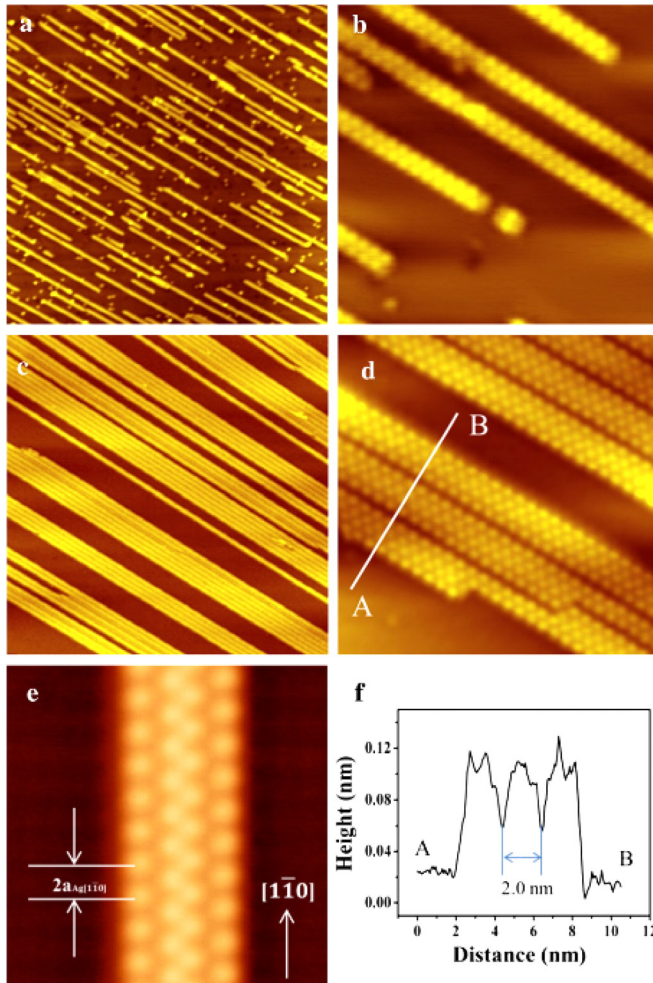


FIG. 17. (a) STM topographic image of silicon deposited on Ag(110) surface at room temperature. (b) High resolution STM image (taken at $15 \times 15 \text{ nm}^2$ at $V = 1.1 \text{ V}$) of the 1 nm wide SiNRs. Reprinted with permission from Feng *et al.*, *Surf. Sci.* **645**, 74 (2016). Copyright 2016 Elsevier.

affected by the chirality and the size of the SiNRs due to edge effects.¹⁰⁶ It was reported that the Young modulus of the SiNRs increases as the size of the NR increases.

NRs forms of materials may exhibit edge-type- and width-dependent magnetic and electronic properties. Zhao and Ni studied the magnetic and electronic properties of SiNRs with a different edge structure which was called sawtooth-edged SiNRs (SSiNRs).¹⁰⁷ It was found that SSiNRs are more stable than the zigzag-edged SiNRs and have FM spin-semiconductor character with an intrinsic gap between the majority and minority spin states. It was predicted that an applied small tensile strain can make the material more sensitive to an external electric field which can be used to tune its electronic properties. With all these findings, it was suggested that SSiNRs may have potential for applications in spintronic devices. Song *et al.* investigated the effect of the edge structure and the width of SiNRs on the structural and electronic properties.¹⁰⁸ They considered both edge shapes, zigzag and armchair, with H passivation for SiNRs and found that an edge state appears in zigzag SiNRs at the Fermi level, E_F , which cannot be observed in all armchair SiNRs. It was found that increasing the width of armchair

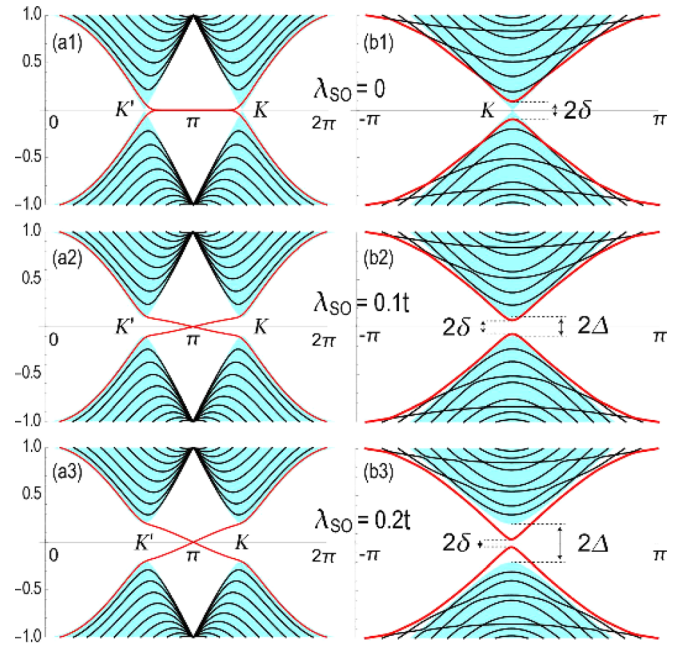


FIG. 18. Band structure of ((a1), (a2), and (a3)) zigzag and ((b1), (b2), and (b3)) armchair nanoribbons for width of $N = 16$. The vertical axis is the energy in units of t and the horizontal axis is the momentum k . The cyan region (red curve) represents the band of the bulk (edge). The bandgap of the bulk (edge) is denoted by 2Δ (2δ) which increases (decreases) as λ_{SO} increases. Reprinted with permission from M. Ezawa and N. Nagaosa, *Phys. Rev. B* **88**, 121401 (2013). Copyright 2013 American Physical Society.

SiNRs, both an oscillating behavior and a periodic feature of $\Delta_{3n} > \Delta_{3n+1} > \Delta_{3n+2}$ for integer n were predicted.

Spin-dependent magnetic properties in crystals are a determinative property for their applications in spintronic devices. Fu *et al.* studied the spin-dependent Seebeck effect (SDSE) in H-terminated zigzag-edged SiNRs and found that

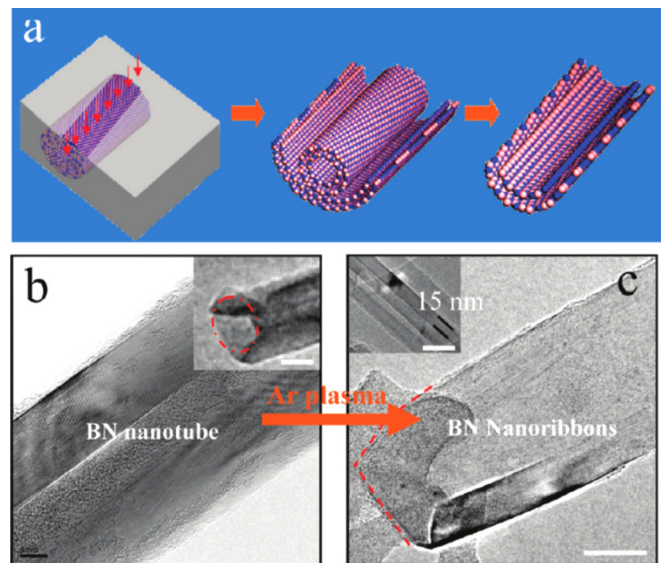


FIG. 19. Unwrapping of MWBNNTs. (a) Schematic representation of the unwrapping processes induced by plasma etching, and exfoliating of tube walls to form BNNRs. (b) and (c) Morphology transition typical TEM images of the products before and after etching. The inset in (b) reveals the open and nearly circular end of the initial tube, and the inset in (c) shows four formed ribbons; the scale bars are 20 nm. Reprinted with permission from Zeng *et al.*, *Nano Lett.* **10**, 5049 (2010). Copyright 2010 American Physical Society.

applying temperature difference between source and drain results in oppositely flowing spin-up and spin-down currents indicating thermal spin currents in zigzag SiNRs.¹⁰⁹ Creating opposite spin currents reduces the conducting electron current in the material and thus, the related Joule heating is much suppressed which indicates potential applications of zigzag SiNRs in low-power-consumption technology. An *et al.* studied spin-polarized currents in SiNRs by applying local exchange field and reported that upon applying a weak local exchange field parallel to the surface of SiNRs on one of the edges of the NR, a gap is induced in the corresponding edge states while another pair of gapless edge states with opposite spin are still protected by time-reversal symmetry.¹¹⁰ It was pointed out that spin-polarized current can be obtained in the absence of Rashba spin-orbit coupling and in the presence of a very weak exchange field. Saari *et al.* showed that in terms of an inhomogeneous electric field, conducting channels can be localized in SiNRs.¹¹¹ In the same way, it is possible to break the spin degeneracy of these conducting channels. They mentioned that silicene type group IV elements can be of potential for spintronic applications with manipulated spin currents. Moreover, tunability of spin and charge transport in SiNRs having zigzag edge shape were investigated by Shakouri *et al.*¹¹² They found that the band structure of zigzag SiNR lacks spin inversion symmetry in the presence of intrinsic SOC in combination of an external electric field and an exchange field. Moreover, for certain energy ranges of the incoming electrons, SiNR was found to possess a controllable high-efficiency spin polarizing behavior.¹¹³

Very recently, Zare *et al.* studied the topological phase and dependency of Ruderman-Kittel-Kasuya-Yosida (RKKY) interaction on the edge states in zigzag SiNRs.¹¹⁴ It was found that from the band dispersion of zigzag SiNRs, topological phase transition can be investigated in detailed by using RKKY interaction. It was shown that the exchange coupling is significantly enhanced due to the zero-energy edge states of the zigzag SiNRs. Moreover, it was revealed that three different magnetic phases, spiral, FM, and AFM, can exist under different values of an external electric field for a system of two magnetic impurities which are located on the edges of zigzag SiNR. In addition, Ezawa and Nagaosa studied the edge channels of SiNRs and found that the behavior of the helical edge channels (HECs) strongly depends on the shape of the edge.¹¹⁵

B. NRs of germanene and stanene

Like monolayer silicene, the 2D form of germanium, germanene, has been synthesized as a buckled monolayer. Due to its relatively high spin-orbit gap, it was considered as an ideal candidate to exhibit the quantum spin Hall effect at experimentally accessible temperatures.

NRs of germanene have been proposed theoretically. Pang *et al.* investigated the electronic and magnetic properties of both pristine and chemically doped GeNRs and found that a single B or N substitution can induce a transition from semiconducting to metal in armchair GeNRs.¹¹⁶ In addition, a single B or N doping turns AFM-semiconducting zigzag

GeNRs into FM-semiconductor. Bayani *et al.* studied the optical properties of hydrogenated GeNRs and the properties of H sensitive FET based on GeNRs.¹¹⁷ The stable structure, binding energy, and depleted charge in armchair GeNRs for different amounts of H₂ concentrations were obtained and it was found that increasing the H₂ concentration also increases the binding energy and the transferred amount of charge. In addition, for the armchair GeNR with 5 chain width, the effect of H₂ concentration on the transport properties of GeNRs was investigated and found that under the same applied bias voltage, current through the GeNR increases with increasing H₂ concentration. To obtain the optical properties, the dielectric functions were calculated for parallel and perpendicular polarizations and the dielectric function was found to be anisotropic, and the dielectric constant decreases as the H₂ concentration increases. Wang *et al.* predicted that in H-passivated zigzag edge SiNRs and GeNRs, half-metallicity can be induced by applying an in-plane electric field.¹¹⁸ It was reported that H-passivated zigzag edge SiNRs have a longer spin relaxation time and spin-diffusion length with larger magnetic stability when compared to 2D silicene.

Stanene, consisting only of Sn atoms, is a 2D material having many physical properties similar to those of silicene and germanene which was recently synthesized on Bi₂Te₃ (111).¹¹⁹ The 1D NR form of stanene has not been synthesized experimentally but was already investigated theoretically.

1D NR form of Sn (SnNR) has not been synthesized yet but theoretical investigations were achieved on its fundamental properties. Xiong *et al.* studied the electronic and magnetic properties of SnNRs and reported that armchair stanene NRs (ASnNRs) are NM semiconductors, while zigzag SnNRs (ZSnNRs) possess AFM semiconducting ground state.¹²⁰ In addition, for bandgap of ASnNRs, a periodic oscillating behavior with the width was found. However, an inverse relation was found between the bandgap of ZSnNRs and the width. Investigating I–V characteristic of materials is important for realizing its bandgap and device performance. van den Broek *et al.* investigated the current-voltage characteristic of armchair stanene NRs (ASnNRs) and found that without any strain SnNRs carry higher currents for low biases when compared with the other group-IV NRs.¹²¹ It was analyzed that the bandgap of ASnNRs depends on the width of the ribbon. In addition, it was shown that for a certain width the SnNRs exhibit comparable contact resistance independent of the increasing sp^3 hybridization character. In another study, van den Broek and his co-workers studied the electronic structure and transport properties of ASnNRs and reported that due to the sp^2 - sp^3 hybridization the electronic structure can be tuned by applying out-of-plane electric field and in-plane uniaxial strain.¹²² It was reported that since stanene has the largest buckling among the group-IV monolayers, these external effects decrease the current for SnNRs with about 50% in I–V characteristic. It was also shown that when the polarization energy becomes comparable to the quantum confinement bandgap, a bandgap is induced and the effective mass increases. In addition to these studies, edge states in both hydrogen terminated and bare zigzag SnNRs

(ZSnNRs) were investigated by Hattori *et al.* Without hydrogen terminations, the energy spectra of multi-orbital model and single-orbital model are different for low buckled ZSnNRs.¹²³ For the hydrogenated case, it was revealed that due to the strong spin-orbit interaction the degeneracy of the edge states is removed and helical edge states with dispersion appear.

VIII. NRs OF GROUP III-V COMPOUNDS

A. 1D form of white graphene: h-boron nitride NRs (BNNRs)

Following the successful synthesis of graphene, synthesis of 2D monolayer form of hexagonal boron nitride (h-BN) was also achieved.¹²⁴ 2D monolayer h-BN has attracted great attention due to its various outstanding properties such as high thermal conductivity, low dielectric constant, chemical inertness, and high mechanical strength which make this material important for a wide range of applications.

Like its 2D form, 1D NRs of h-BN were also widely studied. Chen *et al.* fabricated BN hollow NRs (BNHNRs) by using ZnS NR as a template since it can be synthesized easily by CVD.¹²⁵ The fabricated BNHNRs have high crystallinity and demonstrate an ultraviolet cathodoluminescence (CL) emission at 5.33 eV which is important for applications in optoelectronics. In another study, Zeng *et al.* produced few- and single-layer BNNRs, mostly with zigzag edges, by unwrapping multiwalled BN nanotubes (MWBNTs) through plasma etching.¹²⁶ It was found that the synthesized NRs possess semiconducting behavior due to vacancy defects and doping-like conducting edge states. It was also shown that the produced BNNRs have mainly N-terminated zigzag edges exhibiting high currents of 2 μ A under an applied voltage of 9 V and a high conductance of 104 S/m. Furthermore, *ab-initio* calculations demonstrated that experimentally observed surface vacancies are the driving sources for the distinct carrier transport in BNNRs. Wei *et al.* studied substitutional C-doping in BNNRs with *in situ* electron beam irradiation in an energy-filtering 300 kV HRTEM.¹²⁷ It was shown that C substitutions preferentially occur at the sites which are more vulnerable to electron beam irradiation like the edges of the BNNRs. In addition, it was observed that BNNRs can be transformed from an insulator to a conductor upon C doping in agreement with the previous theoretical predictions.

Especially after synthesis of BNNRs, theoretical studies have gained a lot of interest to analyze and propose unknown physical properties of BNNRs. Samarakoon and Wang investigated half-metallicity property in hydrogenated BNNRs and found that zigzag-edged BNNRs can possess intrinsic half-metallic feature upon full hydrogenation.¹²⁸ In addition, this half-metallic behavior was reported to be tunable under applied transverse electric bias which is a promising route for spintronic applications. Similar results were also found by Topsakal *et al.*¹²⁹ They found that armchair BNNRs are NM semiconductors, while the one with zigzag edges are metallic but they can also display FM semiconducting behavior upon hydrogen passivation of both edges. In addition, it was shown that the bandgap of armchair BNNRs can

be widened upon passivation of B and N with H atoms. Furthermore, it was pointed out that magnetic and electronic properties of zigzag BNNRs strongly depend on edge passivation whether the B or N edge is saturated with H. In another study, Lopez-Bezanilla *et al.* investigated electronic and magnetic properties of BNNRs under edge functionalization with different types of atoms.¹³⁰ It was shown that in contrast to H passivated NM semiconducting zigzag BNNRs, Oxygen (O) edge-terminated zigzag BNNRs can have two energetically degenerate FM metallic ground states on the B edges. However, the S edge terminated NRs were found to have NM metallic ground state. It was suggested that O and S functionalizations play crucial roles in zigzag BNNRs for the use in electronic devices. In addition to these types of atoms, properties of fluor passivated zigzag edge BNNRs were studied by Zeng *et al.*¹³¹ It was demonstrated that the transition from half-metallic character to the semiconducting one can be observed in zigzag BNNRs by fluorination at different sites or by tuning the amount of fluorination. In addition, it was reported that 8-chain wide zigzag BNNRs with 1 and 8 F atoms possess perfect spin-filtering effect and negative differential resistance (NDR) behavior.

In all of the materials, it is very common to have defective structures while they are being synthesized. Theoretical investigations demonstrate that existence of such defects in a crystal may affect the magnetic and electronic properties of the material. Li *et al.* studied the effect of line defects on the electronic and magnetic properties of BNNRs.¹³² It was found that line-defect-embedded zigzag BNNRs whose edges are chemically homogeneous and B-terminated are AFM semiconductors in their ground state. However, those with N-terminated edges were reported to be metallic with both AFM and FM states. In addition, line-defect-embedded zigzag BNNRs with hydrogen passivation were found to be NM semiconductors with notably reduced bandgap which occurs due to the impurity states. Qi *et al.* investigated the piezoelectric properties of BNNRs and reported that the bandgap of zigzag-edged BNNRs can be tuned under uniaxial tensile strain.¹³³ In addition, it was shown that due to the structural asymmetry and H passivation, sizable dipole moment and piezoelectric effect can be found in these NRs.

B. h-AlN-NRs: Edge dependent magnetism

Although NRs of Aluminum nitride (AlNNRs) have not been synthesized yet, there are several theoretical studies on this structure. In one of them, Zhang *et al.* investigated the effects of the dangling bond on the electronic and magnetic properties of AlNNRs.¹³⁴ It was found that the dangling bonds in zigzag AlNNRs result in a magnetic semimetallic ground state with bare N edge, while they result in a magnetic metallic ground state for NRs with bare Al edge. However, for armchair AlNNRs with bare N or Al edges, dangling bonds cause a magnetic semiconducting ground state. It was also shown that due to the number of dangling bonds in zigzag AlNNRs which are half of those in armchair AlNNRs, the magnetic moment is also half of the one of armchair AlNNRs. Du *et al.* studied the structural and electronic properties of zigzag AlNNRs and reported that

H-terminated zigzag AlNNRs having width of 10 chains are NM semiconductors with indirect bandgap.¹³⁵ In addition, it was shown that an external transverse electric field decreases monotonically the bandgap. In another study, Lopez-Bezanilla *et al.* investigated the effect of self-doping on the half-metallicity of AlNNRs and reported that this behavior can be tuned into fully metallic or semiconducting depending on the application of an external electric field or uniaxial strain.¹³⁶ It was shown that as the uniaxial strain is varied from compressive to tensile, a spin-resolved selective self-doping occurs which increases the half-metallicity of the NRs. In addition to these theoretical characterization studies, the effects of doping were also investigated. The structural and electronic properties of C-chain doped AlNNRs were investigated^{137,138} and reported that single C-chain doped AlNNRs, with both zigzag and armchair edges, are still NM semiconductors but the C-chain reduces the bandgap. In addition, for zigzag AlNNRs, C-chain doping can change the direct character of the band structure to indirect one independent of its position.

IX. SUPERSTRUCTURES OF NRs

In addition to the analysis of fundamental properties of NRs, construction of superlattices by using different types of NRs was first predicted by Sahin *et al.*¹³⁹ (see Fig. 20) It was reported that a type-I band alignment can be induced due to the states which are confined to the GaN part of the heterostructure. Chen *et al.* also investigated the electronic properties of gallium nitride NRs (GaNNRs) and possible AlN/GaN NR heterojunctions.¹⁴⁰ It was found that the bandgap of GaNRs is sensitive to the width of the ribbon and decreases monotonically with the increase in the width. The ribbons with zigzag edge are indirect semiconductors, while the ones with armchair edge are direct gap semiconductors. It was shown that for AlN/GaN NRs the bandgap increases monotonically with the increase of the AlN concentration in the heterojunction. Dai *et al.* also studied the same structures and reported similar results.¹⁴¹ Chandiramouli studied the transport properties of gallium arsenide NRs (GaAsNRs) based molecular devices and reported that under applied bias voltage the peak maximum in both valence and conduction bands increases.¹⁴² It was shown that the electron density is mostly localized on the As sites through GaAsNR and thus, the transmission spectrum provides the transmission of electrons at different energy intervals across GaAsNR.

Heterostructures of NRs can be obtained especially using structurally similar single layer materials such as MoS₂-WS₂, Si-Ge-Sn, or Graphene-hBN. Randhawa *et al.* studied the thermoelectric transport properties of hybrid Si-Ge NRs.¹⁴³ The value for the thermoelectric figure of merit of hybrid Si-Ge NRs increases with the number of interfaces used in the hybrid NR. This was shown especially for Si-Ge-Si-Ge-Si NR (with 4 interfaces) and Si-Ge-Si NR (with 2 interfaces) that the thermoelectric figure of merit of the first hybrid NR was found to be enhanced as compared with that of the second one.

There are also several studies on hybrid NRs of B, N, and C atoms. Seol and Guo studied the bandgap tuning in

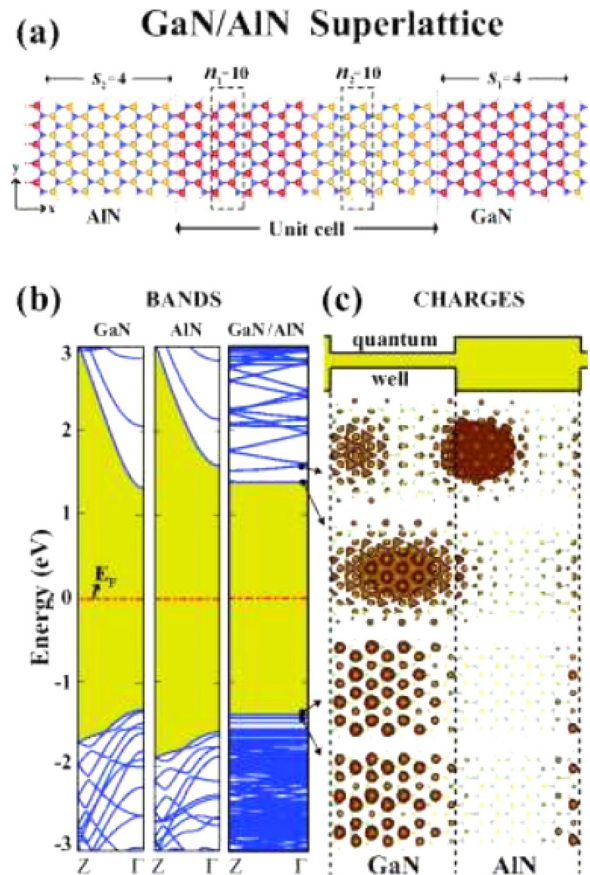


FIG. 20. (a) A superlattice formed by periodically repeating heterostructure of armchair NRs of GaN-AlN compounds. Red, yellow, blue, and small balls represent Ga, Al, N, and H atoms, respectively. (b) Energy band structures of constituent GaNRs, AlNNRs, and resulting superlattice. The bandgaps are shaded by yellow. (c) Band decomposed isosurface charge densities for lowest two conduction band and highest two valence bands. Reprinted with permission from Sahin *et al.*, Phys. Rev. B **80**, 155453 (2009). Copyright 2009 American Physical Society.

AGNRs which are confined by BNNRs.¹⁴⁴ It was found that H-terminated AGNRs have a nearly zero bandgap for width of $3N + 2$, while the ones confined by BNNRs exhibit considerable bandgap. It was pointed out that this fact originates from the change in potential energy of C atoms in the edge of AGNR that is close to B and N atoms in BNNR. In another study, He *et al.* obtained a transition from insulator to metallic character in hybridized graphene and boron nitride NRs.¹⁴⁵ In addition, the electronic and transport properties of zigzag-edged BNNR and GNR were investigated. The bandgap can be tuned by changing the width of the ZGNR and transition from insulator to semiconductor, half-semimetal, and metal can be induced for certain number of zigzag BNNR and ZGNR atoms.

As an example of heterostructures of TMDs, both 1D and 2D forms of the MoS₂-WS₂ were investigated. Kang *et al.* investigated the band alignment tunability and charge localization of heterostructures of MoS₂-WS₂.¹⁴⁶ They found that under applied tensile strain on WS₂ region, a type-II to type-I band alignment transition can take place. In addition, it was shown that the presence of the grain boundary introduces localized in-gap states. Moreover, they reported that the carrier localization is tunable under varying of the width of

the constituents of the superlattice. Recently, Zhang *et al.* theoretically predicted the thermoelectric properties of MoS₂-WS₂ based hybrid NRs¹⁴⁷ and showed that the hybrid NRs exhibit higher efficiency of energy conversion than their individual NRs due to the fact that the MoS₂/WS₂ interface reduces lattice thermal conductivity more than the electron transport. Furthermore, it was revealed that depending on the number of the interfaces between MoS₂/WS₂ NRs, a figure of merit ZT as high as 5.5 can be achieved at a temperature of 600 K.

X. SUMMARY

In this study, we reviewed the synthesis techniques, characterization methods, fundamental properties, and state-of-the-art applications of nanoribbons of ultrathin two-dimensional crystal structures.

Here, we show that synthesis and usage of these NR materials are important due to their controllable synthesis processes, length, width, and edge shape and edge passivation possibilities. GNRs are pointed out as 1D structures with ultranarrow width and thickness. In addition, width and edge-shape dependent magnetic and electronic properties are promising for their optoelectronic applications. Zigzag edge MoS₂ NRs are reported to exhibit width-independent physical properties with suitable bandgap for various applications. As anisotropic materials BPNRs and ReS₂ NRs have unique properties such as growing time dependent morphology for ReS₂ NRs and very high Seebeck coefficient for BPNRs. As a member of TMTs, TiS₃ NRs are mentioned to have high electron mobility and edge-dependent electronic properties. Moreover, from the group of C element, SiNRs are reported to be very flexible materials and temperature-dependent width in synthesis process is pointed out as an important remark. Through the same group in periodic table, SnNRs are announced to have high currents for low voltages without any strain. As a member of group III–V compounds, NRs of h-BN are known to exhibit edge-passivation-dependent magnetic and electronic properties. Furthermore, recent theoretical investigations reveal the existence of superlattices of NRs which addresses the enhanced electronic, thermal, and transport properties.

Our review demonstrates that size, edge-type, and thickness in 1D NRs of novel 2D materials can strongly affect their electronic, magnetic, optical, and mechanical properties. Recent advances in nanoscale material research have revealed that 1D ultra-thin nanoribbons are not only essential for demonstration of enhanced quantum effects which promise some interesting discoveries but also important due to their possible use in nanotechnology applications.

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